固体素子による量子技術: シリコン

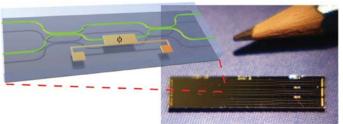
阿部 英介

理化学研究所 創発物性科学研究センター

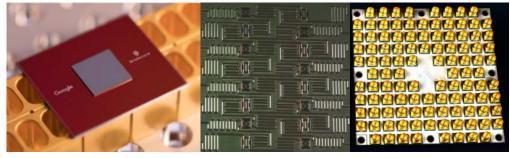
応用物理特別講義A 2020年度春学期後半金曜4限@14-202オンライン講義

量子技術のプラットフォーム

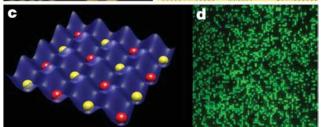




超伝導回路

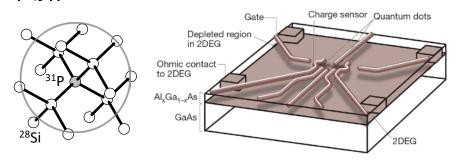


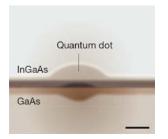
©Google ©IBM ©Intel

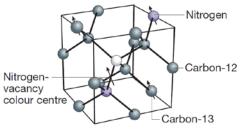


捕捉イオン/冷却原子

半導体スピン

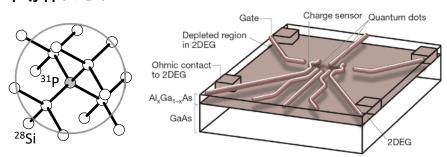




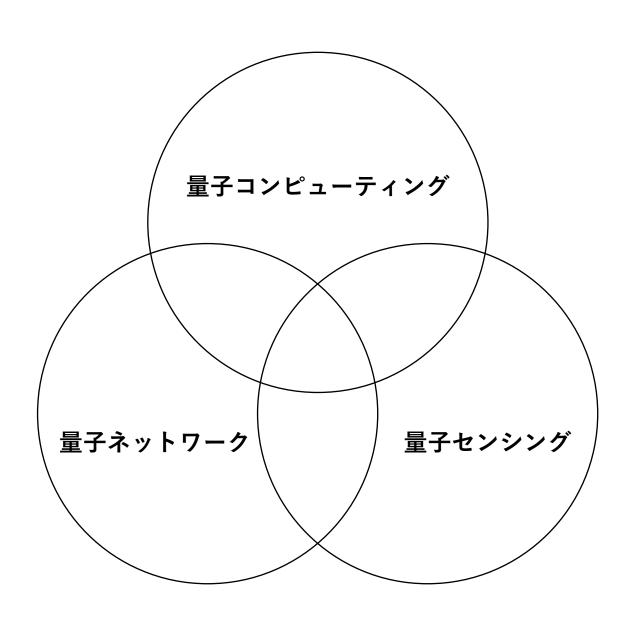


量子技術のプラットフォーム

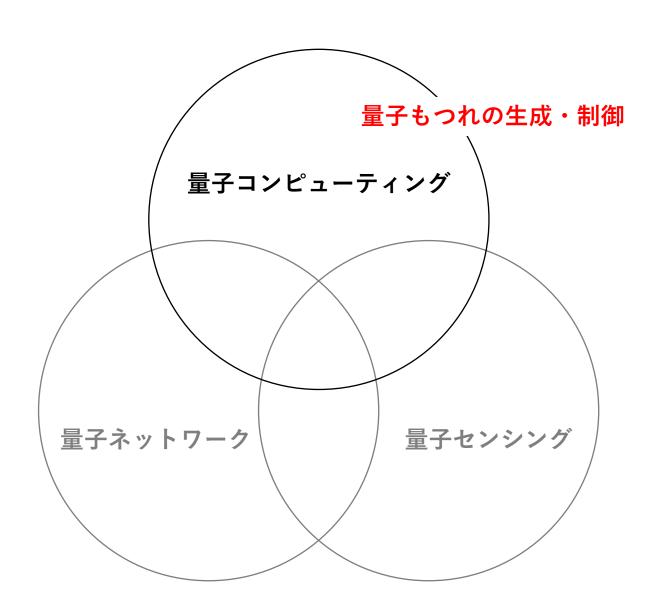
半導体スピン



量子技術



量子技術



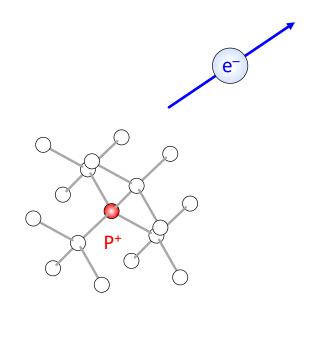
講義內容

- ・ドナースピン
 - アンサンブル
 - 単一ドナー
- 量子ドットスピン
 - MOS量子ドット
 - Si/SiGe量子ドット

講義內容

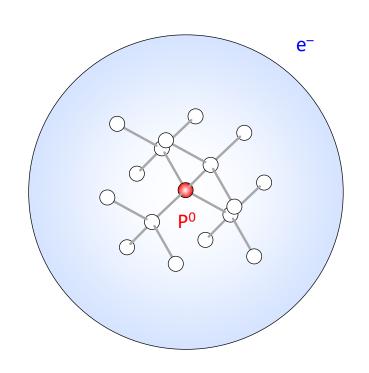
- ドナースピン
 - アンサンブル
 - 単一ドナー
- 量子ドットスピン
 - MOS量子ドット
 - Si/SiGe量子ドット

III (13)	IV (14)	V (15)
В	С	N
Al	Si	P
Ga	Ge	As



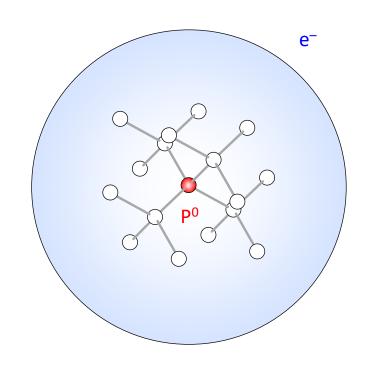
室温では100%イオン化 → 自由電子として電気伝導に寄与

III (13)	IV (14)	V (15)
В	С	N
Al	Si	P
Ga	Ge	As



低温下(< 10 K): 電子はリンに束縛される
→ 水素原子様浅い不純物

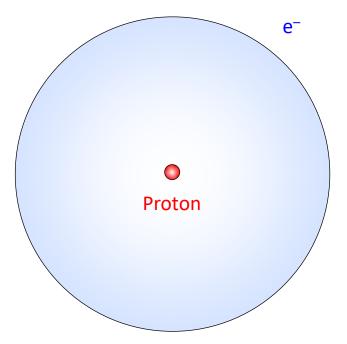
III (13)	IV (14)	V (15)
В	С	N
Al	Si	P
Ga	Ge	As

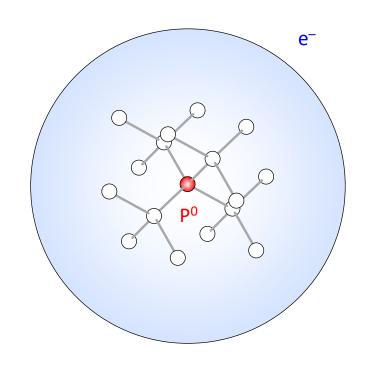


有効Bohr半径: a_B^* = 3.2 nm

格子定数: a_{si} = 0.54 nm

水素原子

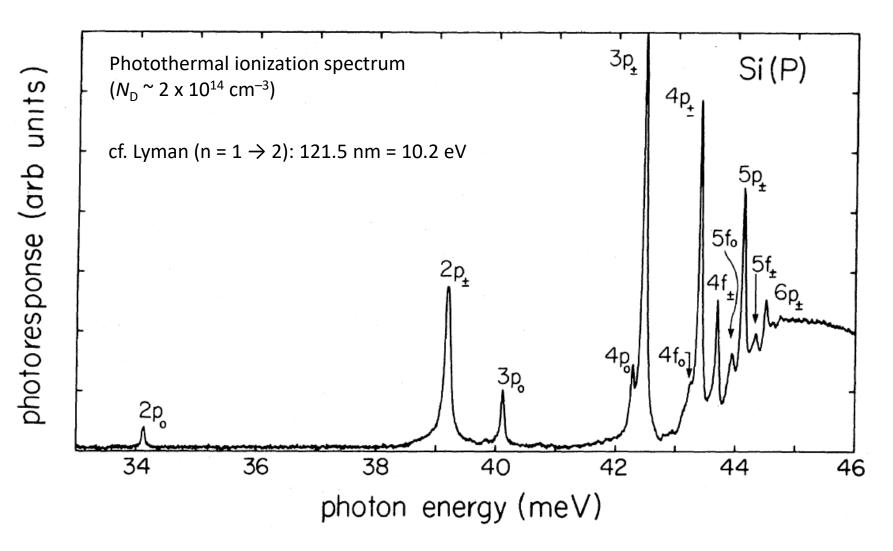




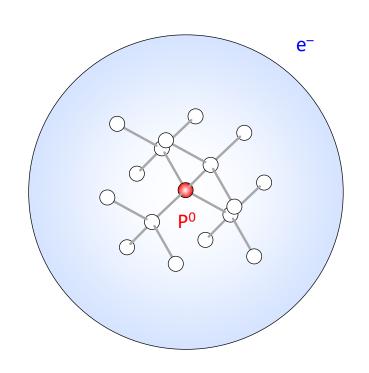
Bohr半径: $a_{\rm B}$ = $\varepsilon_0 h^2/\pi m e^2$ = 0.053 nm

有効Bohr半径: $a_B^* = 3.2 \text{ nm}$

格子定数: a_{si} = 0.54 nm

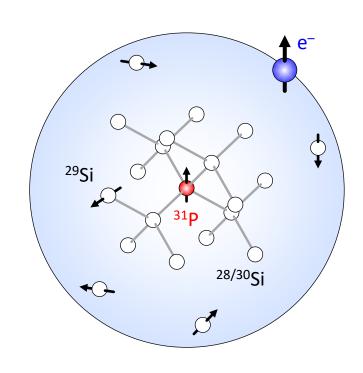


III (13)	IV (14)	V (15)
В	С	N
Al	Si	P
Ga	Ge	As



低温下(< 10 K): 電子はリンに束縛される
→ 水素原子様浅い不純物

III (13)	IV (14)	V (15)
В	С	N
Al	Si	Р
Ga	Ge	As

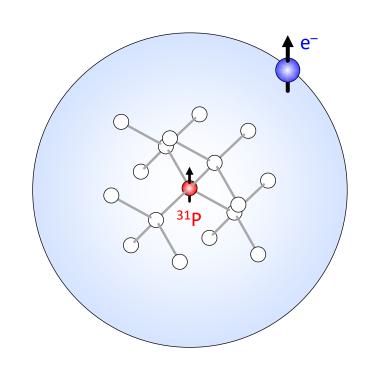


磁気環境

²⁸Si: ²⁹Si ($I = \frac{1}{2}$): ³⁰Si = 92.2%: 4.7%: 3.1%

$$^{31}P (I = \frac{1}{2}) = 100\%$$

III (13)	IV (14)	V (15)
В	С	N
Al	Si	P
Ga	Ge	As



磁気環境

同位体制御²⁸Si → 99.995%

$$^{31}P (I = \frac{1}{2}) = 100\%$$

スピンハミルトニアン

$$S_z = \frac{\sigma_z}{2} = \frac{1}{2} \begin{pmatrix} 1 & 0 \\ 0 & -1 \end{pmatrix}$$

$$I_z = \frac{\sigma_z}{2} = \frac{1}{2} \begin{pmatrix} 1 & 0 \\ 0 & -1 \end{pmatrix}$$

$$B_0 \approx 350 \text{ mT}$$

$$\gamma_{\rm e}/2\pi = 27.97~{\rm GHz/T}$$

$$\gamma_{\rm p}/2\pi = 17.23~{\rm MHz/T}$$
 $(\gamma_{\rm H}/2\pi = 42.58~{\rm MHz/T})$

$$a_0/2\pi = 117.53 \text{ MHz}$$
 $(a_H/2\pi = 1420.4 \text{ MHz}, "21-\text{cm line}")$

スピンハミルトニアン

$$H_0 = \gamma_e B_0 S_z - \gamma_P B_0 I_z + a_0 S_z I_z$$

$$= \frac{\gamma_{\rm e} B_0}{2} (\sigma_z \otimes I) - \frac{\gamma_{\rm P} B_0}{2} (I \otimes \sigma_z) + \frac{a_0}{4} (\sigma_z \otimes \sigma_z)$$

$$S_z = \frac{\sigma_z}{2} = \frac{1}{2} \begin{pmatrix} 1 & 0 \\ 0 & -1 \end{pmatrix}$$

$$I_z = \frac{\sigma_z}{2} = \frac{1}{2} \begin{pmatrix} 1 & 0 \\ 0 & -1 \end{pmatrix}$$

$$=\frac{\gamma_{\mathrm{e}}B_0}{2} \begin{pmatrix} 1 & 0 \\ 0 & -1 \end{pmatrix} \otimes \begin{pmatrix} 1 & 0 \\ 0 & 1 \end{pmatrix} - \frac{\gamma_{\mathrm{P}}B_0}{2} \begin{pmatrix} 1 & 0 \\ 0 & 1 \end{pmatrix} \otimes \begin{pmatrix} 1 & 0 \\ 0 & -1 \end{pmatrix} + \frac{a_0}{4} \begin{pmatrix} 1 & 0 \\ 0 & -1 \end{pmatrix} \otimes \begin{pmatrix} 1 & 0 \\ 0 & -1 \end{pmatrix}$$

$$= \frac{\gamma_{e}B_{0}}{2} \begin{pmatrix} 1 & 0 \\ 0 & -1 \end{pmatrix} \otimes \begin{pmatrix} 1 & 0 \\ 0 & 1 \end{pmatrix} - \frac{\gamma_{P}B_{0}}{2} \begin{pmatrix} 1 & 0 \\ 0 & 1 \end{pmatrix} \otimes \begin{pmatrix} 1 & 0 \\ 0 & -1 \end{pmatrix} + \frac{a_{0}}{4} \begin{pmatrix} 1 & 0 \\ 0 & -1 \end{pmatrix} \otimes \begin{pmatrix} 1 & 0 \\ 0 & -1 \end{pmatrix}$$

$$= \begin{pmatrix} \frac{\gamma_{e}B_{0}}{2} - \frac{\gamma_{P}B_{0}}{2} + \frac{a_{0}}{4} & 0 & 0 & 0 \\ 0 & \frac{\gamma_{e}B_{0}}{2} + \frac{\gamma_{P}B_{0}}{2} - \frac{a_{0}}{4} & 0 & 0 \\ 0 & 0 & -\frac{\gamma_{e}B_{0}}{2} - \frac{\gamma_{P}B_{0}}{2} - \frac{a_{0}}{4} & 0 \\ 0 & 0 & 0 & -\frac{\gamma_{e}B_{0}}{2} + \frac{\gamma_{P}B_{0}}{2} + \frac{a_{0}}{4} \end{pmatrix}$$

$$|\uparrow\uparrow\rangle \qquad |\uparrow\downarrow\rangle \qquad |\downarrow\uparrow\rangle \qquad |\downarrow\downarrow\rangle$$

スピンハミルトニアン

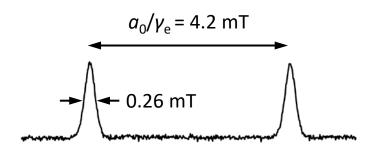
$$H_0 = \gamma_e B_0 S_z - \gamma_P B_0 I_z + a_0 S_z I_z$$

$$B_0 \approx 350 \text{ mT}$$

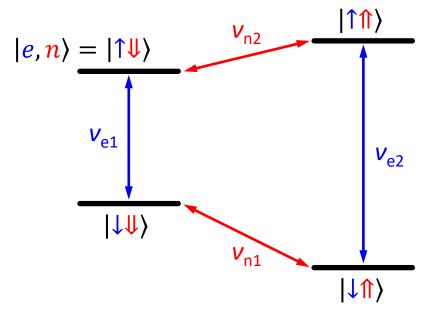
$$\gamma_{\rm e}/2\pi = 27.97 \, {\rm GHz/T}$$

$$\gamma_{\rm P}/2\pi = 17.23 \, {\rm MHz/T}$$

$$a_0/2\pi = 117.53 \text{ MHz}$$



アンサンブル電子スピン共鳴(natSi、磁場掃引)



$$v_{e1} = v_e B_0 - a_0/2$$
 $v_{e2} = v_e B_0 + a_0/2$
 $v_{n1} = a_0/2 + v_p B_0$ $v_{n2} = a_0/2 - v_p B_0$

ディビンチェンゾの要請

1. スケーラブルな量子ビット列

2. 初期化

3. 長いコヒーレンス時間

4. ユニバーサル量子ゲート

5. 射影測定



D. DiVincenzo

©RWTH Aachen U.

ディビンチェンゾの要請

1. スケーラブルな量子ビット列

2. 初期化

- 3. 長いコヒーレンス時間 → T_{2e} = 10 s (*1), T_{2n} = 180 min (*2)
 - 4. ユニバーサル量子ゲート

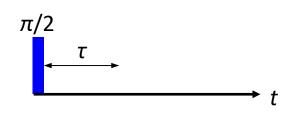
5. 射影測定

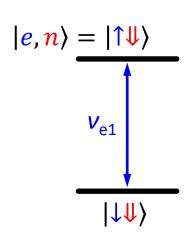
*1: Nature Mat. **11**, 143 (2012) Tyryshkin *et al.*

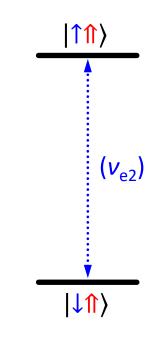
*2: Science **342**, 830 (2013) Saeedi *et al.*

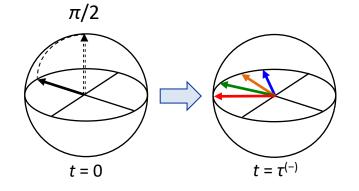
Fortschr. Phys. 48, 771 (2000) DiVincenzo

電子スピンコヒーレンス: T_{2e}





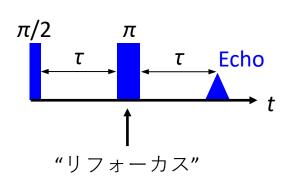


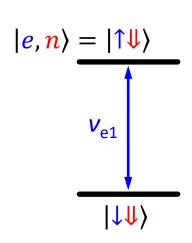


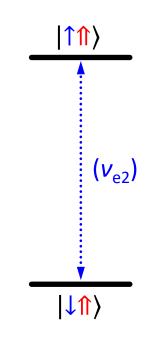
不均一性(29Si由来)による見かけの減衰

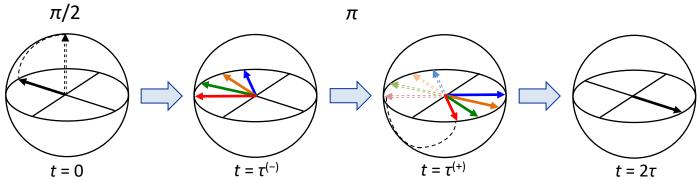
 ${T_{2e}}^* \approx (\gamma_e \ 0.26 \ \text{mT})^{-1} \approx 130 \ \text{ns} \ll T_{2e} \approx 500 \ \mu\text{s}$

電子スピンコヒーレンス: T_{2e}





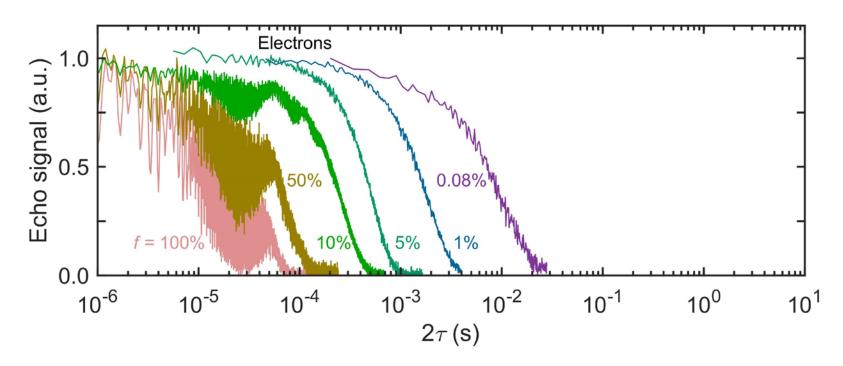




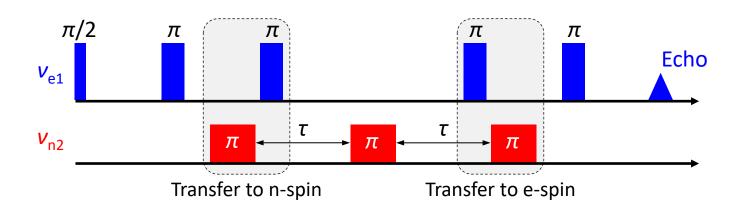
電子スピンコヒーレンス: T_{2e}

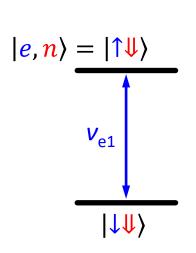
Electron spin coherence of phosphorus donors in silicon: Effect of environmental nuclei

Eisuke Abe,^{1,2,*} Alexei M. Tyryshkin,³ Shinichi Tojo,² John J. L. Morton,^{1,4} Wayne M. Witzel,⁵ Akira Fujimoto,² Joel W. Ager,⁶ Eugene E. Haller,^{6,7} Junichi Isoya,⁸ Stephen A. Lyon,³ Mike L. W. Thewalt,⁹ and Kohei M. Itoh²

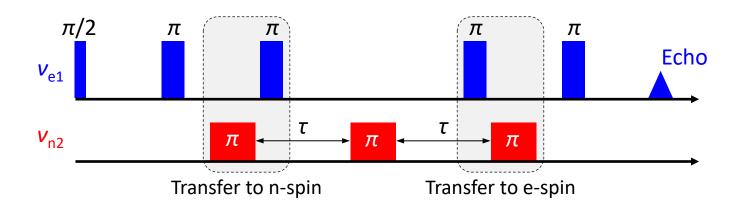


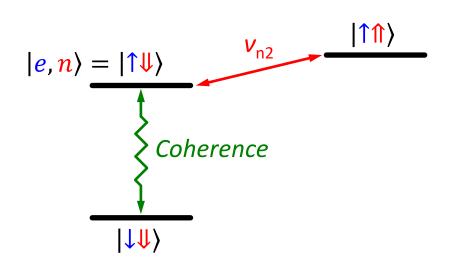
Phys. Rev. B 82, 121201 (2010) Abe et al.

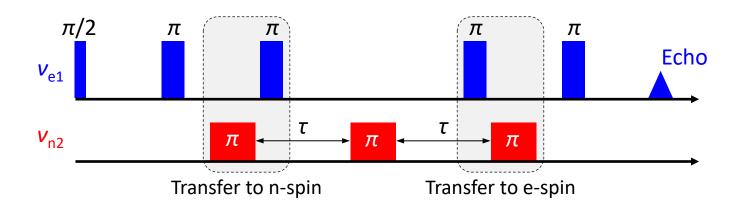


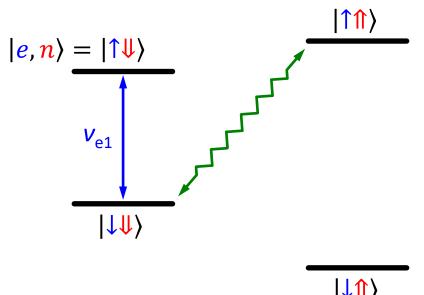


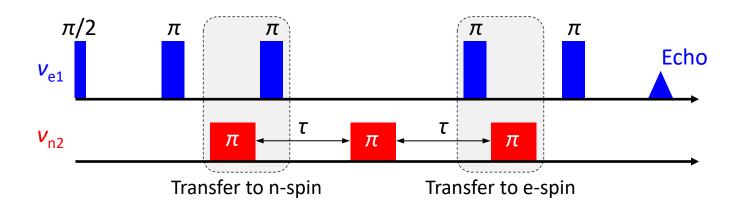
|↑↑}











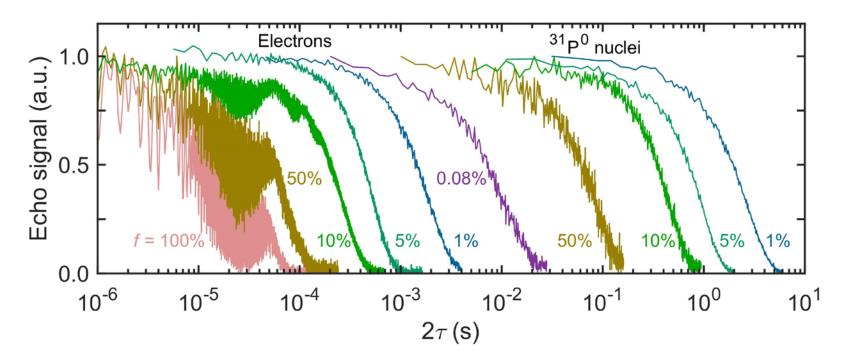
$$|e,n\rangle = |\uparrow \Downarrow \rangle$$

Electron spin coherence of phosphorus donors in silicon: Effect of environmental nuclei

Eisuke Abe,^{1,2,*} Alexei M. Tyryshkin,³ Shinichi Tojo,² John J. L. Morton,^{1,4} Wayne M. Witzel,⁵ Akira Fujimoto,² Joel W. Ager,⁶ Eugene E. Haller,^{6,7} Junichi Isoya,⁸ Stephen A. Lyon,³ Mike L. W. Thewalt,⁹ and Kohei M. Itoh²

Nuclear spin decoherence of neutral ³¹P donors in silicon: Effect of environmental ²⁹Si nuclei

Evan S. Petersen, A. M. Tyryshkin, J. J. L. Morton, E. Abe, S. Tojo, K. M. Itoh, M. L. W. Thewalt, and S. A. Lyon



Phys. Rev. B **93**, 161202 (2016) Petersen et al.

Method of Polarizing Nuclei in Paramagnetic Substances

G. Feher

Bell Telephone Laboratories, Murray Hill, New Jersey (Received May 31, 1956)

OVERHAUSER¹ has shown that a saturation of the electron spin resonance leads to a large enhancement of the nuclear polarization. A necessary condition for this enhancement is that the nuclei relax via the electrons whose resonance is being saturated.

Polarization of Phosphorus Nuclei in Silicon

G. Feher and E. A. Gere

Bell Telephone Laboratories, Murray Hill, New Jersey (Received May 31, 1956)

In the preceding Letter a scheme for polarizing nuclei was described. This Letter deals with the experimental verification of the scheme.

Wolf Prize in Chemistry (2006)

1950年台に固体物理で業績を挙げたのち生物物理(主に光合成)に転向

"...delighted to hear that EPR in Si is sill alive and doing well and has branched out into new and exciting areas" (email to E.A. Dec. 2016)



G. Feher (1924–2017)

©R.A. Icaacson

Phys. Rev. **103**, 500 (1956) Feher Phys. Rev. **103**, 501 (1956) Feher & Gere

Quantum Computation

David P. DiVincenzo

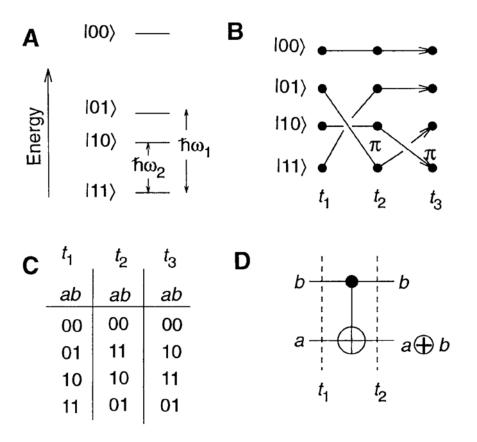


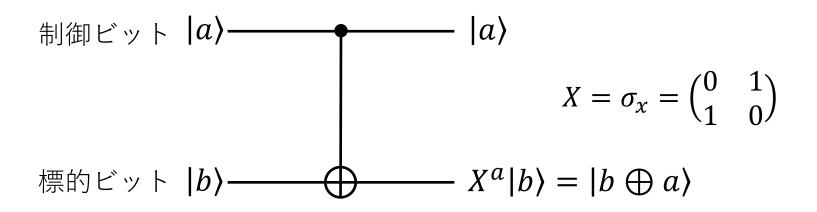
Fig. 2. The action of the two-qubit XOR gate.

The XOR protocol is very closely related to procedures invented long ago in the field of resonance spectroscopies (13). In 1956, Feher introduced a procedure for polarization transfer in electron-nucleus double resonance (ENDOR), which contains the XOR protocol just discussed.

for many purposes in physics, chemistry, and biology, it is highly desirable to move the spin state of an electron onto a nearby nucleus. The fact that this procedure also performs an interesting logical function, XOR, was not previously noted by ENDOR spectroscopists.

制御NOTゲート

制御ビットが1のとき標的ビットを反転



SWAPゲート

$$\begin{vmatrix} a \rangle & & \\ |b \rangle & & \\ |a \rangle & & \\ \end{vmatrix} = \begin{vmatrix} b \rangle & \\ |a \rangle & \\ \end{vmatrix}$$

$$SWAP|00\rangle = |00\rangle
SWAP|01\rangle = |10\rangle
SWAP|10\rangle = |01\rangle
SWAP|11\rangle = |11\rangle$$

$$\Leftrightarrow SWAP = \begin{pmatrix} 1 & 0 & 0 & 0 \\ 0 & 0 & 1 & 0 \\ 0 & 1 & 0 & 0 \\ 0 & 0 & 0 & 1 \end{pmatrix}$$

SWAPゲート

$$\begin{vmatrix} a \rangle & & & \\ |b \rangle & & & \\ |a \rangle & & & \\ \end{vmatrix} = \begin{vmatrix} b \rangle & \\ |a \rangle & \\ \end{vmatrix}$$

SWAP に必要な手続き

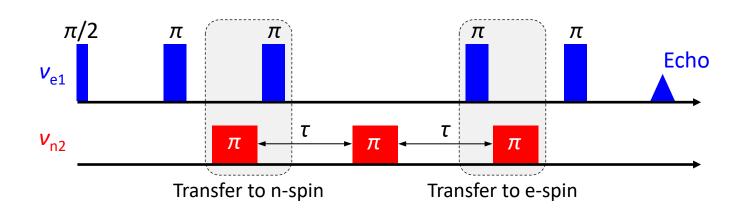
- 第1ビットの情報を第2ビットへ書き込む
- 第2ビットの情報を第1ビットへ書き込む
- 第1ビットの情報を第1ビットから消去する
- 第2ビットの情報を第2ビットから消去する

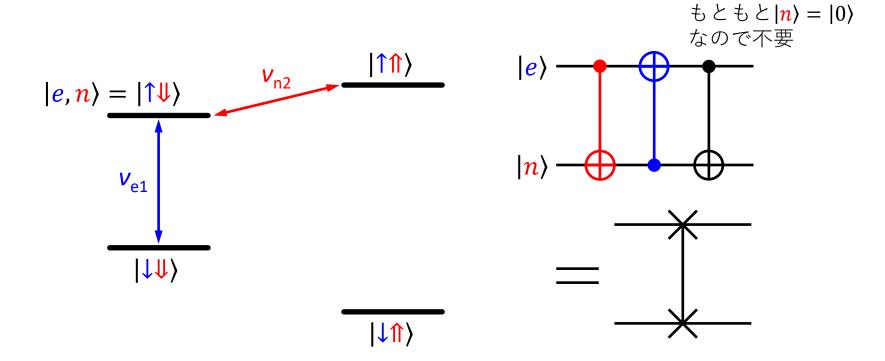
$$|a\rangle|b\rangle \xrightarrow{C_{12}} |a\rangle|b \oplus a\rangle$$

$$\xrightarrow{C_{21}} |a \oplus (b \oplus a)\rangle|b \oplus a\rangle = |b\rangle|b \oplus a\rangle$$

$$\xrightarrow{C_{12}} |b\rangle|(b \oplus a) \oplus b\rangle = |b\rangle|a\rangle$$

ENDOR & SWAP

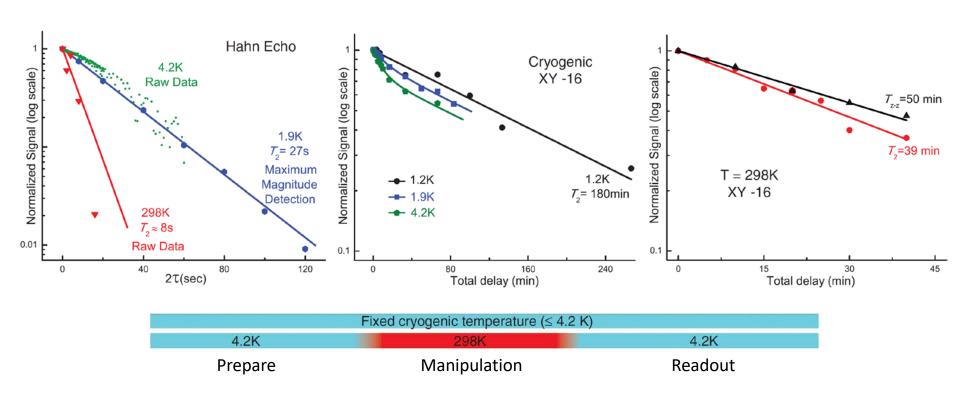




Room-Temperature Quantum Bit Storage Exceeding 39 Minutes Using Ionized Donors in Silicon-28

Auger-electron-detected NMR

Kamyar Saeedi, ¹ Stephanie Simmons, ² Jeff Z. Salvail, ¹ Phillip Dluhy, ¹ Helge Riemann, ³ Nikolai V. Abrosimov, ³ Peter Becker, ⁴ Hans-Joachim Pohl, ⁵ John J. L. Morton, ⁶ Mike L. W. Thewalt ^{1*}



レポート課題 2 (20点)

低磁場におけるSi:Pのスピンハミルトニアンは

$$H_1 = \gamma_{\rm e} B_0 S_z - \gamma_{\rm P} B_0 I_z + a_0 \mathbf{S} \cdot \mathbf{I}$$

と書かれる。ただし

$$\mathbf{S} \cdot \mathbf{I} = \frac{1}{2} \begin{pmatrix} \sigma_{\chi} \\ \sigma_{y} \\ \sigma_{z} \end{pmatrix} \cdot \frac{1}{2} \begin{pmatrix} \sigma_{\chi} \\ \sigma_{y} \\ \sigma_{z} \end{pmatrix} = \frac{1}{4} \left(\sigma_{\chi} \otimes \sigma_{\chi} + \sigma_{y} \otimes \sigma_{y} + \sigma_{z} \otimes \sigma_{z} \right)$$

である。

- (1) *H*₁を4x4行列で表せ。基底は|↑♠⟩, |↑♥⟩, |↓♠⟩, |↓♥⟩の順とする。
- $(2) H_1$ を対角化し、4つ固有値を B_0 の関数として求めよ。

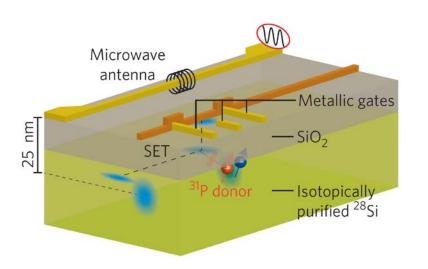
ヒント: (1)より $|\uparrow\uparrow\uparrow\rangle$, $|\downarrow\downarrow\rangle$ は対角的であることが示されるので、 $|\uparrow\downarrow\rangle$, $|\downarrow\uparrow\uparrow\rangle$ に対する2x2行列Aについて永年方程式 $|A-\lambda I|=0$ を解けばよい。

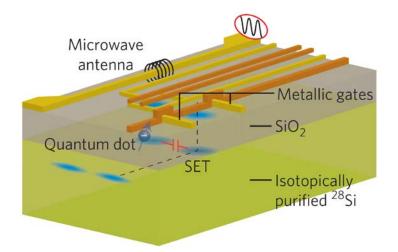
(3) 十分大きな磁場($B_0\gg a_0/\gamma_{\rm e}$)では、 H_1 と H_0 の固有値は一致することを確認せよ。

講義內容

- ドナースピン
 - アンサンブル
 - 単一ドナー
- 量子ドットスピン
 - MOS量子ドット
 - Si/SiGe量子ドット

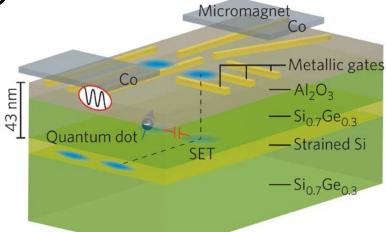
Si単一スピン量子ビット





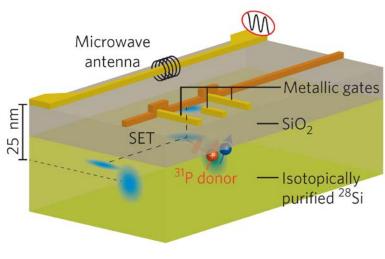
単一リンドナー

MOS量子ドット

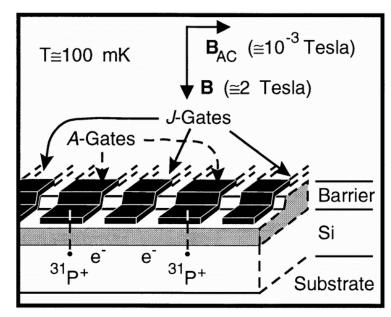


Si/SiGe量子ドット

Si単一スピン量子ビット



単一リンドナー



98年の提案から10年以上を掛けて実験が進展@豪国

Nature **393**, 133 (1998) Kane Nature Nano. **9**, 966 (2014) Schreiber & Bluhm

ディビンチェンゾの要請

1. スケーラブルな量子ビット列

2. 初期化

3. 長いコヒーレンス時間

4. ユニバーサル量子ゲート

5. 射影測定

ディビンチェンゾの要請

- 1. スケーラブルな量子ビット列→スピン系における最大の課題
- 2. 初期化→ スピン緩和(*T*₁), スピン依存トンネル etc
- 3. 長いコヒーレンス時間 $\rightarrow T_{2e} = 10 \text{ s}, T_{2n} = 180 \text{ min}$
- 4. ユニバーサル量子ゲート→ 1量子ビット制御 + CNOT
- **5. 射影測定** → スピン-電荷変換

精度) > 99% ティ(忠実度,

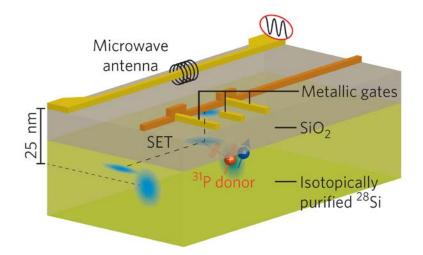
ディビンチェンゾの要請

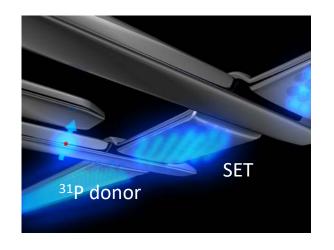
- 1. スケーラブルな量子ビット列→スピン系における最大の課題
- ②. 初期化→ スピン緩和(T₁), スピン依存トンネル etc
 - 長いコヒーレンス時間
 →量子誤り訂正(T₂→∞)
- **4.** ユニバーサル量子ゲート
 → 1量子ビット制御 + CNOT
- **5. 射影測定** → スピン-電荷変換



Single-shot readout of an electron spin in silicon

Andrea Morello¹, Jarryd J. Pla¹, Floris A. Zwanenburg¹, Kok W. Chan¹, Kuan Y. Tan¹, Hans Huebl¹†, Mikko Möttönen^{1,3,4}, Christopher D. Nugroho¹†, Changyi Yang², Jessica A. van Donkelaar², Andrew D. C. Alves², David N. Jamieson², Christopher C. Escott¹, Lloyd C. L. Hollenberg², Robert G. Clark¹† & Andrew S. Dzurak¹

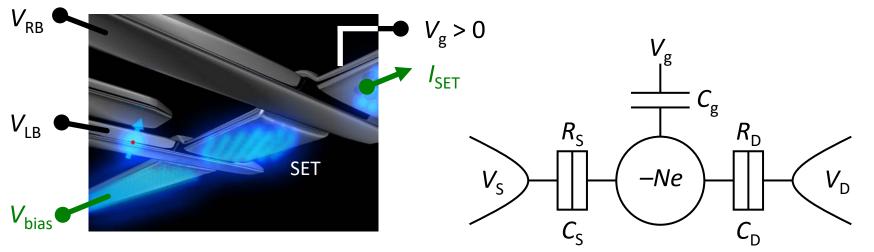




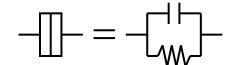


単電子トランジスタ

(aka 量子ドット)



定相互作用モデル(Constant interaction model)

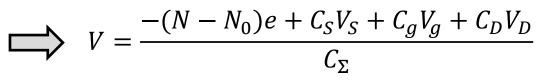


- **SET**をキャパシタ回路でモデル化
- SET内にはN個の電子
- V_{RB,LB}はドットが形成されたら固定(C_{S/D}, R_{S/D}に寄与)
- V_g はQD準位の操作のみで電流は流れない

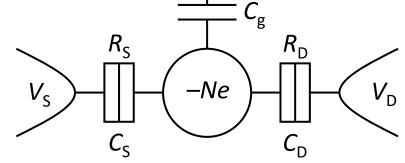
定相互作用モデル

SETの電荷Qと電圧V

$$Q = -(N - N_0)e = C_S(V - V_S) + C_g(V - V_g) + C_D(V - V_D)$$



$$C_{\Sigma} = C_S + C_g + C_D$$
 N_0 : 背景正電荷の補償分



全エネルギー

$$U(N) = \frac{1}{2C_{\Sigma}} \left[-(N - N_0)e + C_S V_S + C_g V_g + C_D V_D \right]^2 + \sum_{n=1}^{N} E_n$$

$$= \frac{e^2}{2C_{\Sigma}} N^2 - \frac{e^2}{C_{\Sigma}} N N_0 - \frac{e}{C_{\Sigma}} N \left(C_S V_S + C_g V_g + C_D V_D \right) + E_N + \cdots$$

定相互作用モデル

電気化学ポテンシャル

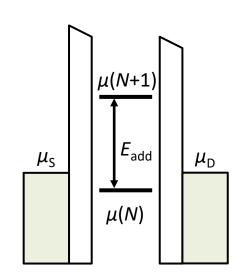
$$\mu(N) \equiv U(N) - U(N-1)$$

$$= \frac{e^2}{C_{\Sigma}} \left(N - N_0 - \frac{1}{2} \right) - \frac{e}{C_{\Sigma}} \left(C_S V_S + C_g V_g + C_D V_D \right) + E_N$$

付加(addition)エネルギー

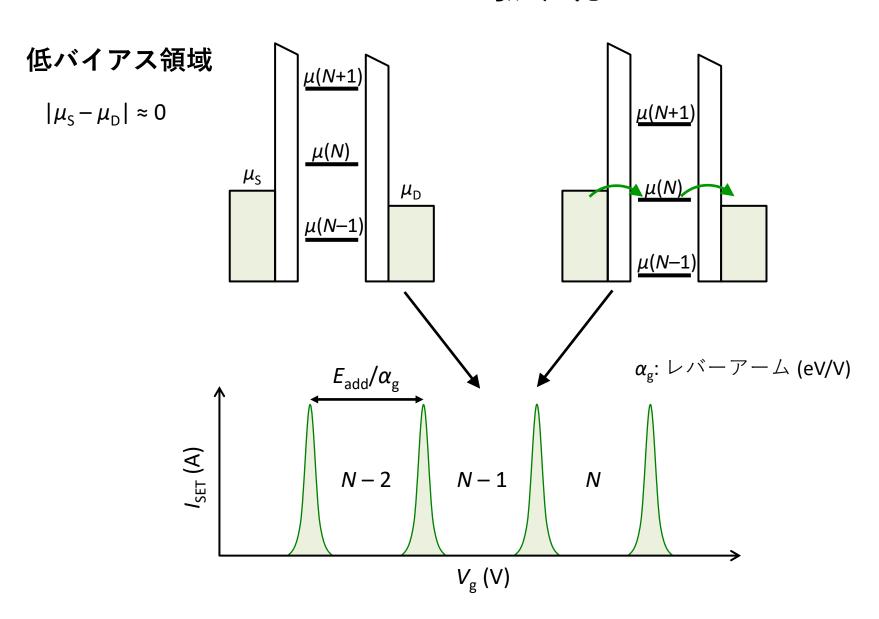
$$E_{\mathrm{add}}(N) = \mu(N+1) - \mu(N) = E_C + \Delta E$$

$$E_C = \frac{e^2}{C_{\Sigma}}$$
:帯電エネルギー

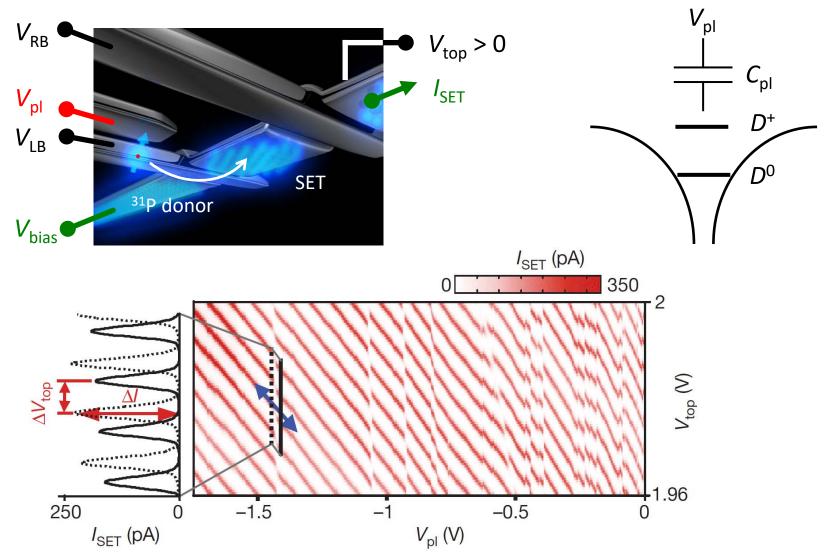


SET準位、ソース、ドレインの μ の相対位置で伝導を理解する

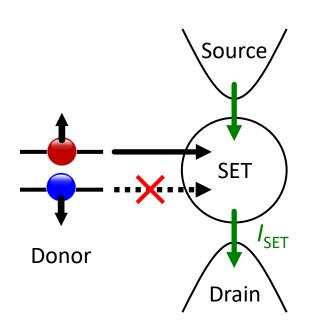
クーロン振動



ドナー-SETハイブリッド



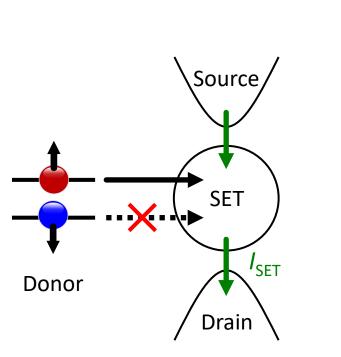
スピン-電荷変換

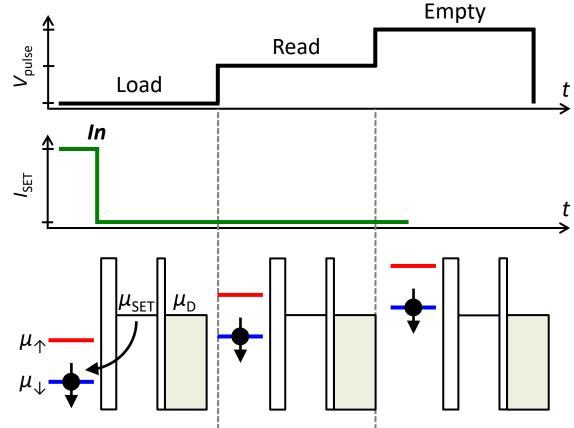


$$E(D^{+}) - E(D^{0}) = 45 \text{ meV}$$

 $E_{C} = 1.5 \text{ meV}$
 $E_{z} = 28 \text{ GHz} = 116 \text{ } \mu\text{eV} \text{ } @B_{0} = 1 \text{ T}$
 $T_{\text{elec}} = 200 \text{ mK} = 17 \text{ } \mu\text{eV}$

スピン測定(小)





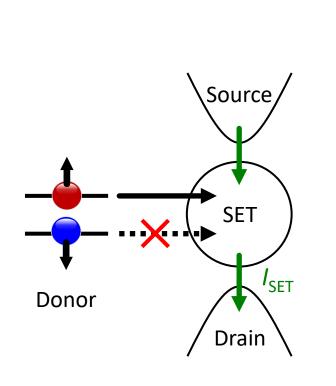
$$E(D^+) - E(D^0) = 45 \text{ meV}$$

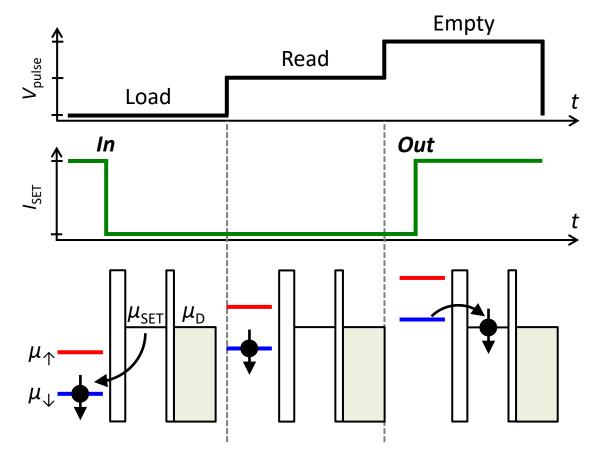
$$E_{\rm C} = 1.5 \; {\rm meV}$$

$$E_z = 28 \text{ GHz} = 116 \mu \text{eV} @B_0 = 1 \text{ T}$$

$$T_{\rm elec}$$
 = 200 mK = 17 μeV

スピン測定(小)





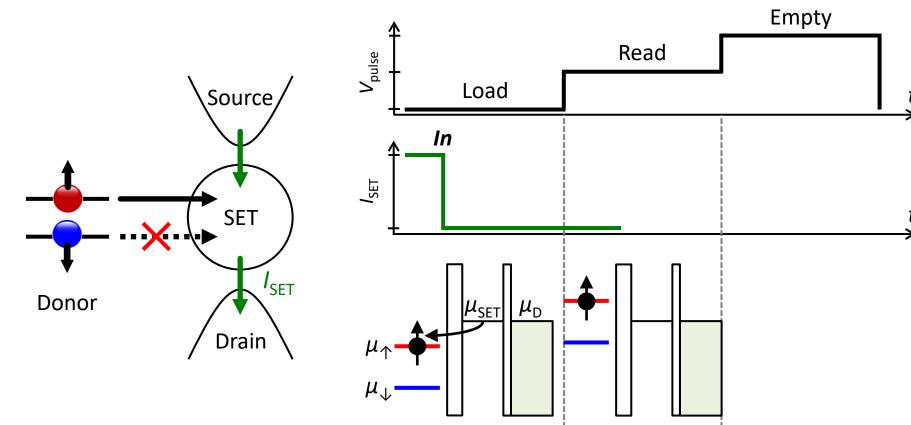
$$E(D^+) - E(D^0) = 45 \text{ meV}$$

$$E_{\rm C} = 1.5 \; {\rm meV}$$

$$E_z = 28 \text{ GHz} = 116 \mu \text{eV} @B_0 = 1 \text{ T}$$

$$T_{\rm elec}$$
 = 200 mK = 17 μeV

スピン測定(个)



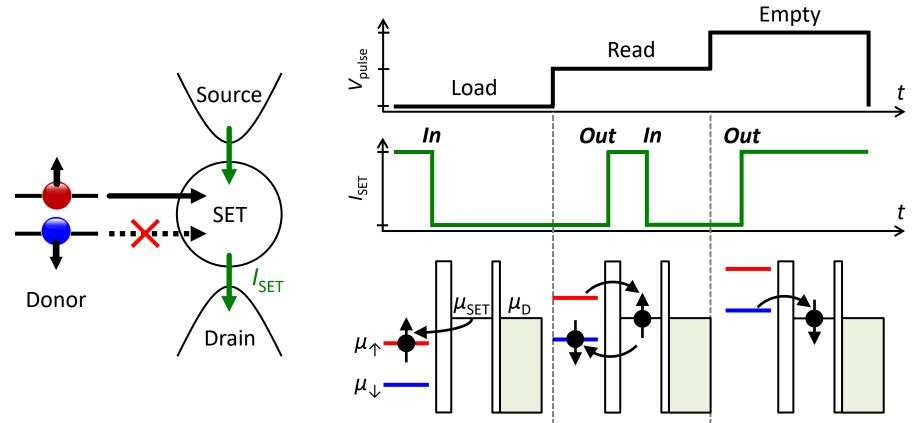
$$E(D^+) - E(D^0) = 45 \text{ meV}$$

$$E_{\rm C} = 1.5 \; {\rm meV}$$

$$E_z = 28 \text{ GHz} = 116 \mu \text{eV} @B_0 = 1 \text{ T}$$

$$T_{\rm elec}$$
 = 200 mK = 17 μeV

スピン測定(个)



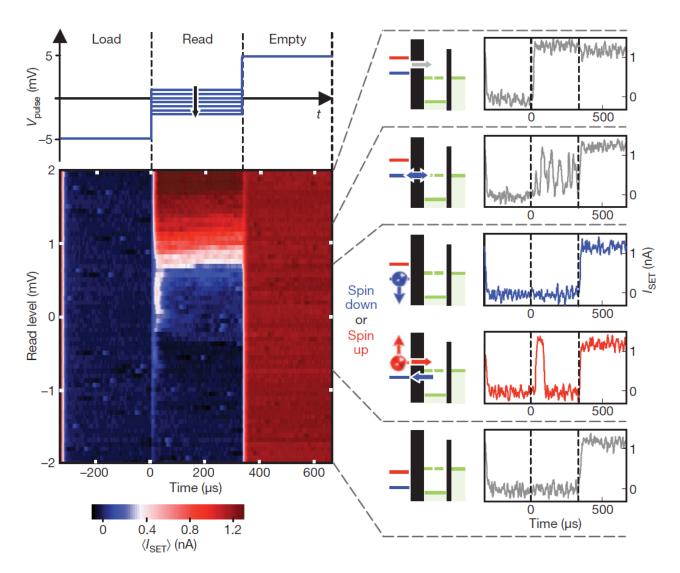
$$E(D^+) - E(D^0) = 45 \text{ meV}$$

$$E_{\rm C} = 1.5 \; {\rm meV}$$

$$E_z = 28 \text{ GHz} = 116 \mu \text{eV} @B_0 = 1 \text{ T}$$

$$T_{\rm elec}$$
 = 200 mK = 17 μeV

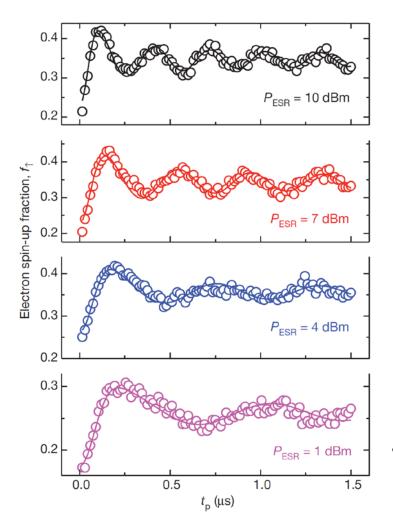
電子スピン単発読み出し

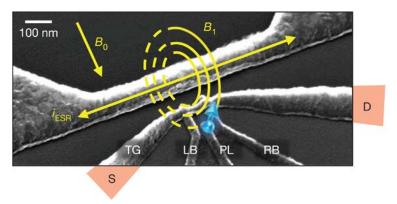


LETTER

A single-atom electron spin qubit in silicon

Jarryd J. Pla¹, Kuan Y. Tan¹†, Juan P. Dehollain¹, Wee H. Lim¹, John J. L. Morton²†, David N. Jamieson³, Andrew S. Dzurak¹ & Andrea Morello¹





Isidor Rabi (1898–1988)

©Nobel Foundation

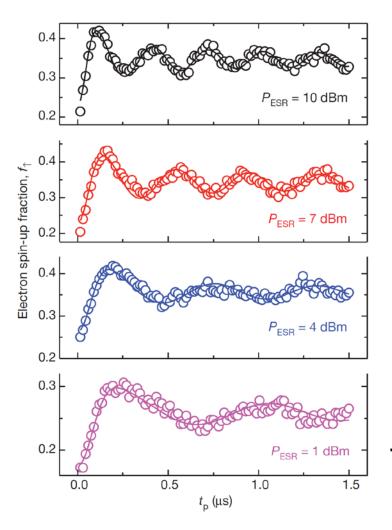


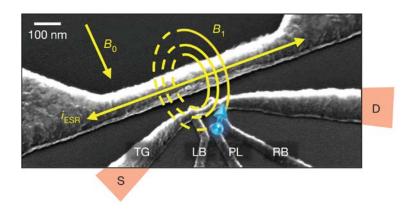
ラビ振動: natSiデバイス

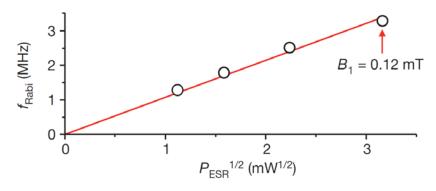
LETTER

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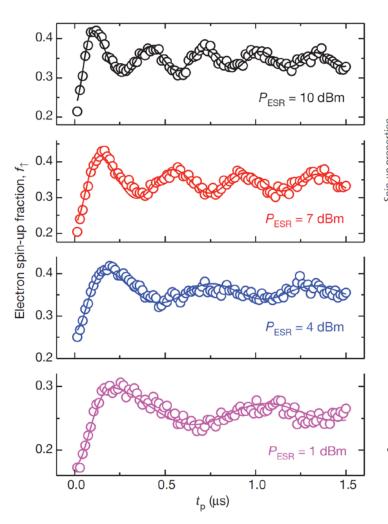


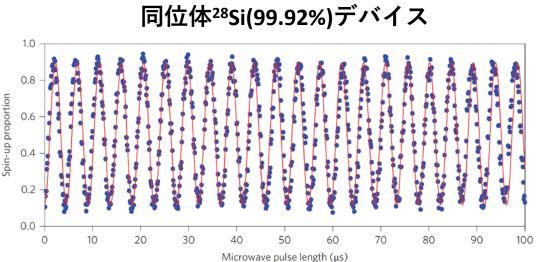
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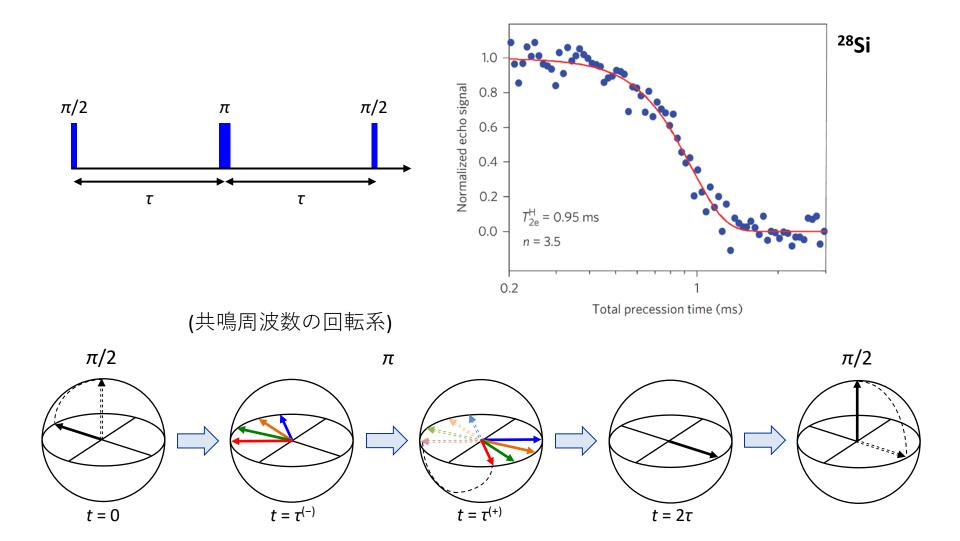




Nature Nano. 9, 986 (2014) Muhonen et al.

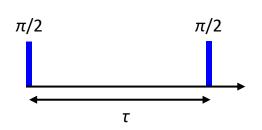
ラビ振動: natSiデバイス

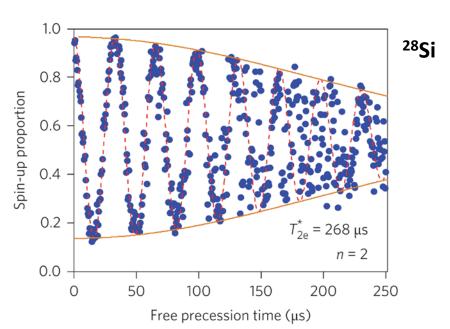
スピンエコー: *T*_{2e}



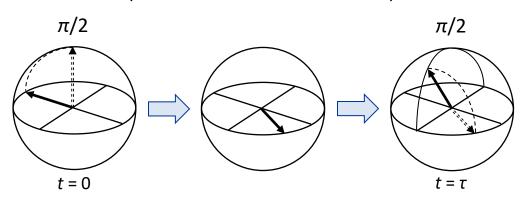
Nature Nano. 9, 986 (2014) Muhonen et al.

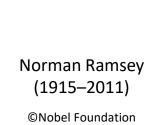
ラムゼー干渉: *T*_{2e}*





(共鳴から少し外れた回転系)



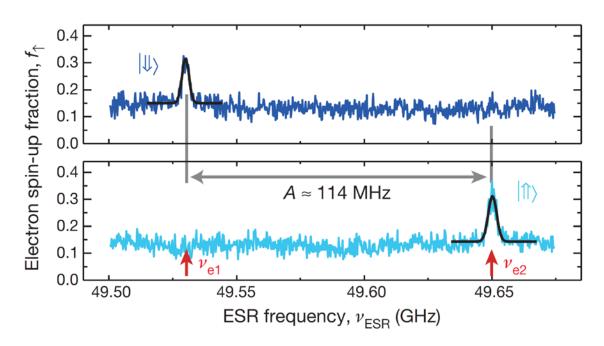






High-fidelity readout and control of a nuclear spin qubit in silicon

Jarryd J. Pla¹, Kuan Y. Tan¹†, Juan P. Dehollain¹, Wee H. Lim¹†, John J. L. Morton², Floris A. Zwanenburg¹†, David N. Jamieson³, Andrew S. Dzurak¹ & Andrea Morello¹

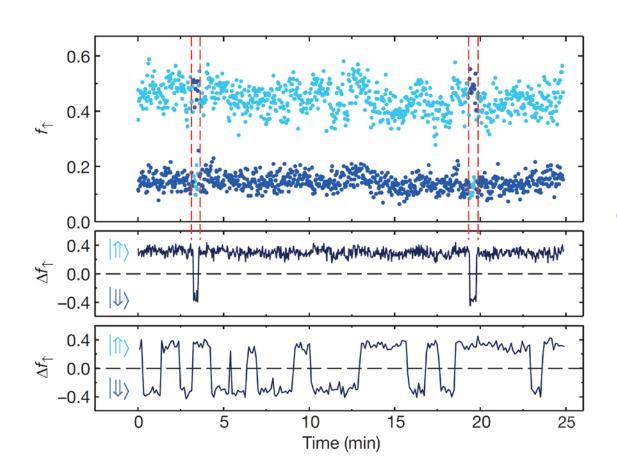


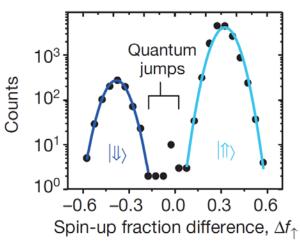
- 電子スピン遷移周波数 $v_{e1,2} = \gamma_e B_0 \mp a_0/2$ は核スピン状態に依存する
- 電子スピン遷移によって核スピン状態は変わらない
- →量子非破壊(QND)測定

LETTER

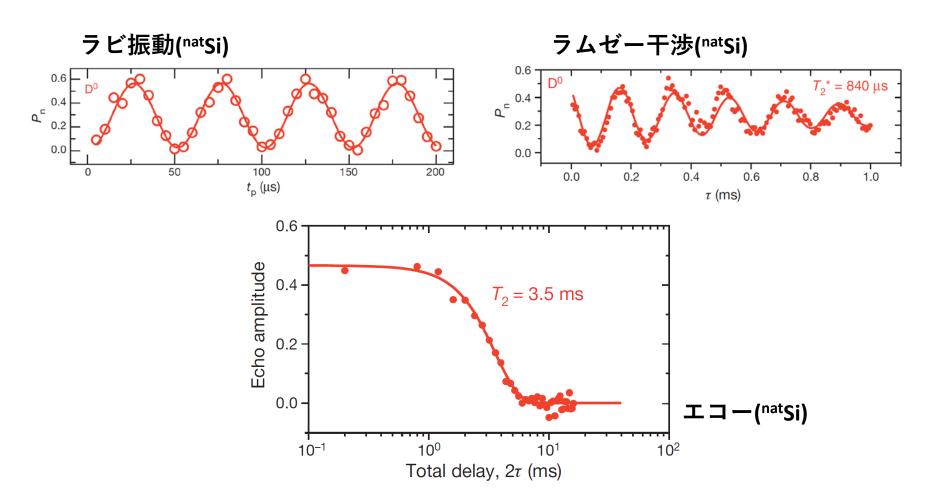
High-fidelity readout and control of a nuclear spin qubit in silicon

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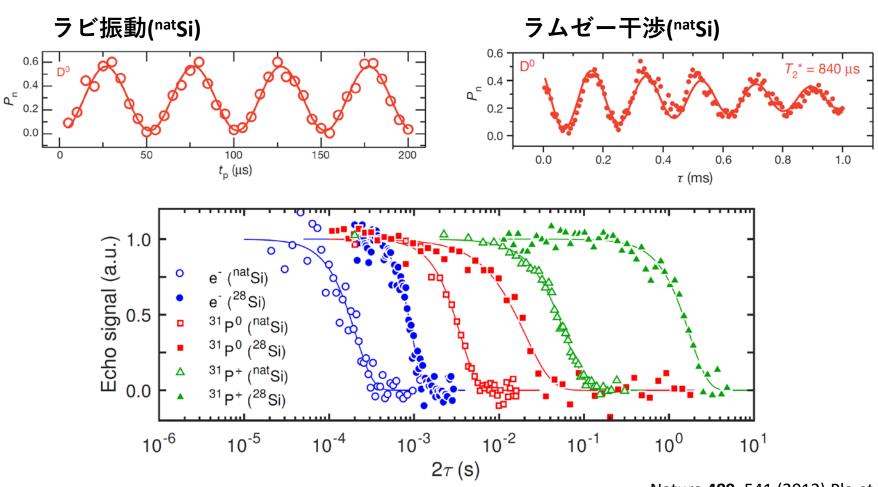




単一核スピンコヒーレント制御



単一核スピンコヒーレント制御



Nature **489**, 541 (2012) Pla et al.

Nature 496, 334 (2013) Pla et al.

Nature Nano. 9, 986 (2014) Muhonen et al.

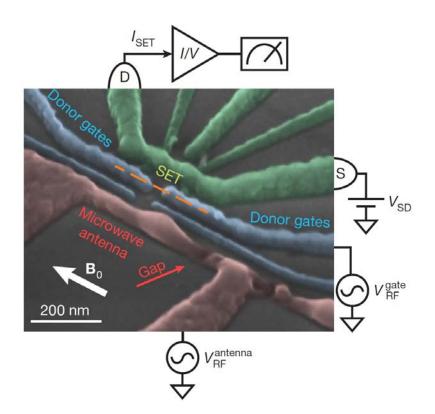
https://doi.org/10.1038/s41586-020-2057-7

Received: 10 June 2019

Accepted: 30 January 2020

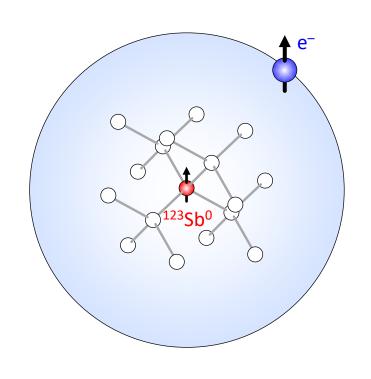
Published online: 11 March 2020

Serwan Asaad^{1,6}, Vincent Mourik^{1,6}, Benjamin Joecker¹, Mark A. I. Johnson¹, Andrew D. Baczewski², Hannes R. Firgau¹, Mateusz T. Mądzik¹, Vivien Schmitt¹, Jarryd J. Pla³, Fay E. Hudson¹, Kohei M. Itoh⁴, Jeffrey C. McCallum⁵, Andrew S. Dzurak¹, Arne Laucht¹ & Andrea Morello^{1⊠}



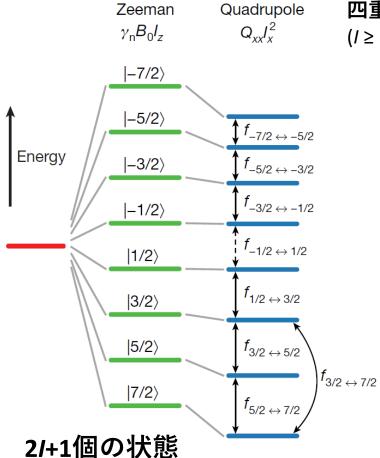
シリコン中のアンチモンドナー

III (13)	IV (14)	V (15)
В	С	N
Al	Si	Р
Ga	Ge	As
		Sb

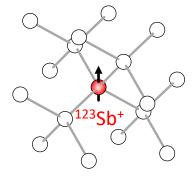


¹²¹Sb (I = 5/2): ¹²³Sb (I = 7/2) = 57.36%: 42.64%

シリコン中のアンチモンドナー



四重極子相互作用: 原子核位置の電場勾配に起因 (/≥1の原子核では電荷分布が球対象でない)



¹²¹Sb (I = 5/2) : ¹²³Sb (I = 7/2) = 57.36% : 42.64%

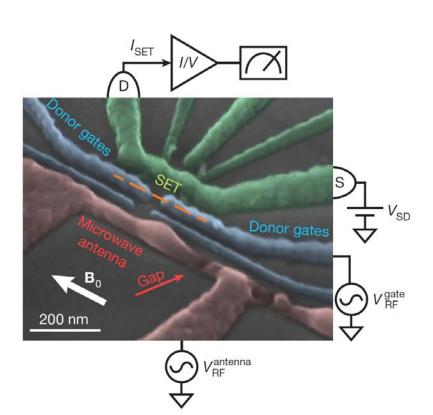
https://doi.org/10.1038/s41586-020-2057-7

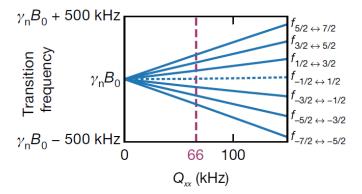
Received: 10 June 2019

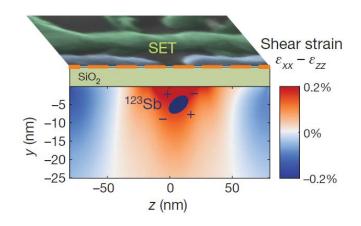
Accepted: 30 January 2020

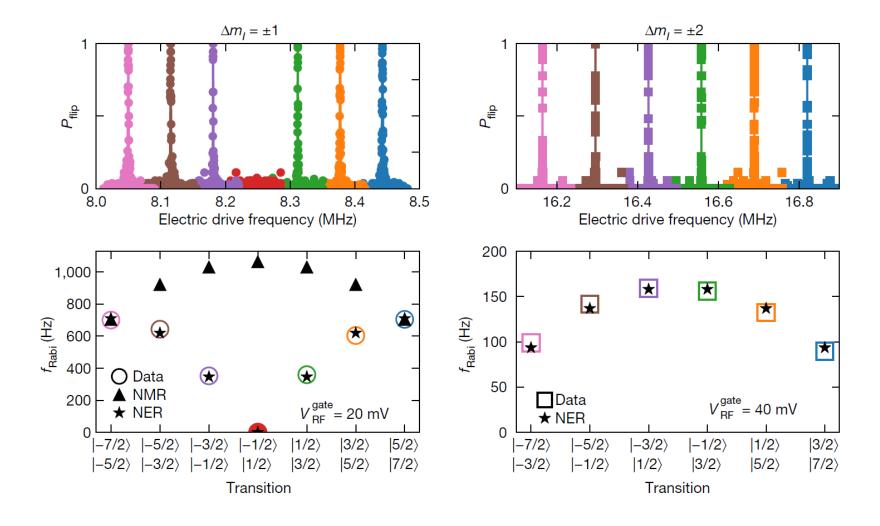
Published online: 11 March 2020

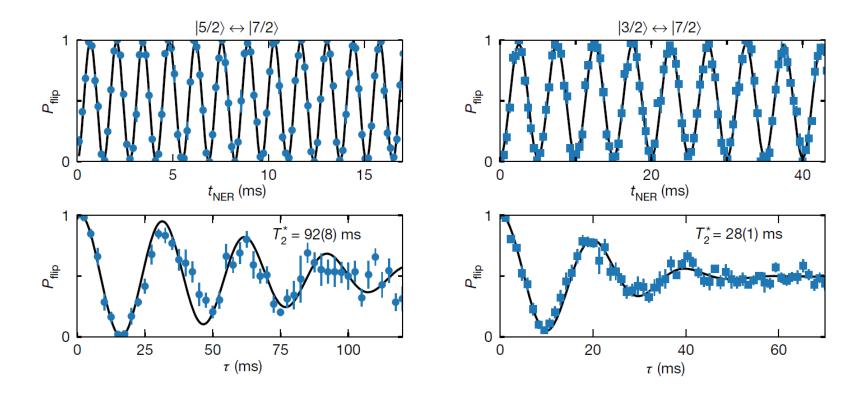
Serwan Asaad^{1,6}, Vincent Mourik^{1,6}, Benjamin Joecker¹, Mark A. I. Johnson¹, Andrew D. Baczewski², Hannes R. Firgau¹, Mateusz T. Mądzik¹, Vivien Schmitt¹, Jarryd J. Pla³, Fay E. Hudson¹, Kohei M. Itoh⁴, Jeffrey C. McCallum⁵, Andrew S. Dzurak¹, Arne Laucht¹ & Andrea Morello¹







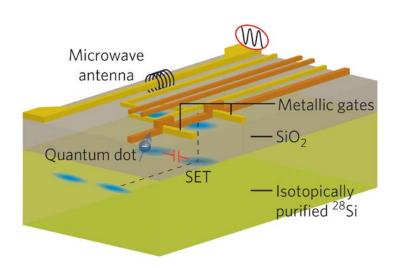




講義內容

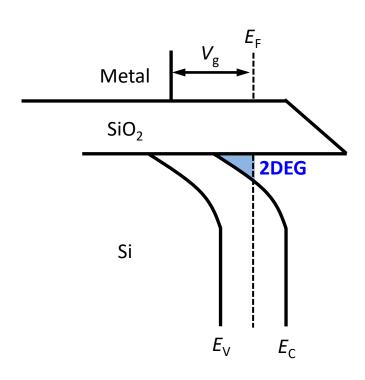
- ・ドナースピン
 - アンサンブル
 - 単一ドナー
- 量子ドットスピン
 - MOS量子ドット
 - Si/SiGe量子ドット

界面MOS構造





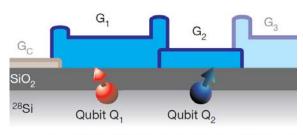
反転層の形成

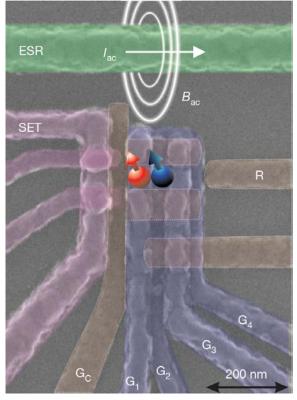


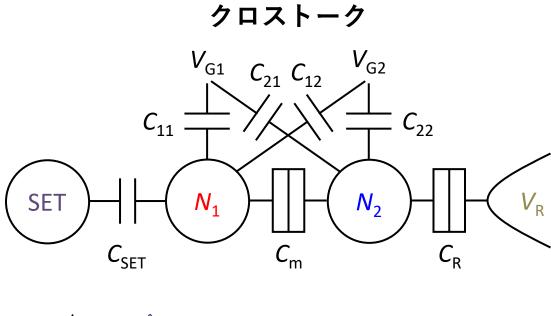
 28 Si : 29 Si ($I = \frac{1}{2}$) : 30 Si = 92.2% : 4.7% : 3.1% → 28 Si = 99.2%

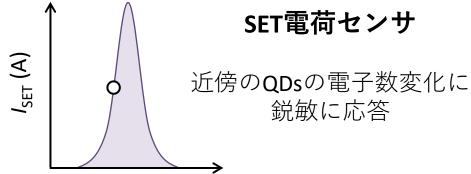
(L to R) J. Muhonen, A. Morello, M. Veldhorst, A. Dzurak

MOS型2重量子ドット

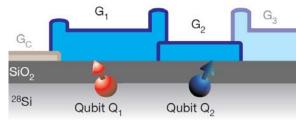


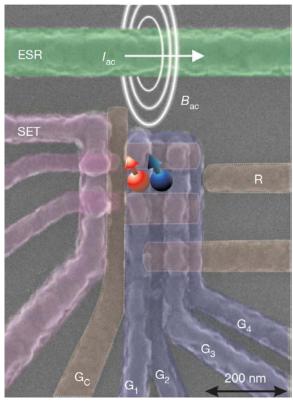


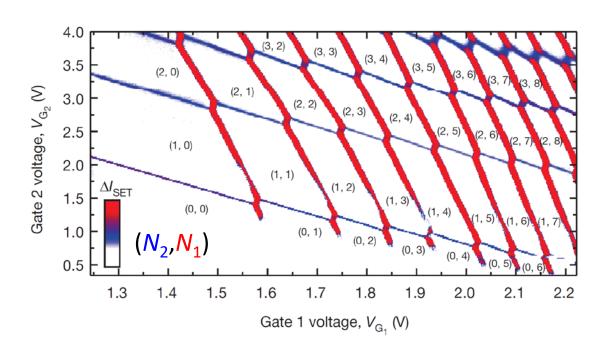




MOS型2重量子ドット

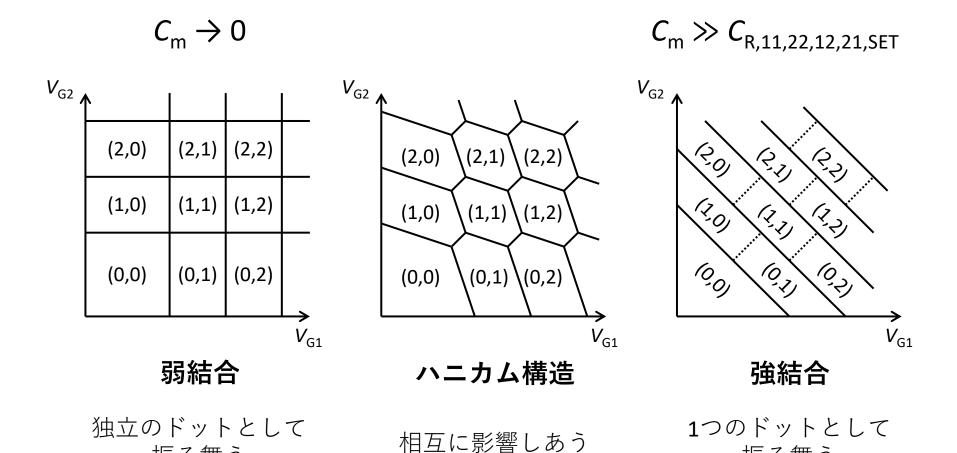






 $*Q_1, Q_2$ の並び方と N_2, N_1 の順番が逆なので見づらい…

スタビリティダイアグラム



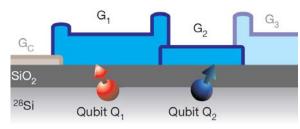
定相互作用モデルで理解できるがここでは省略 >

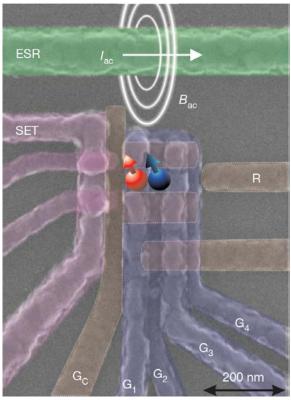
振る舞う

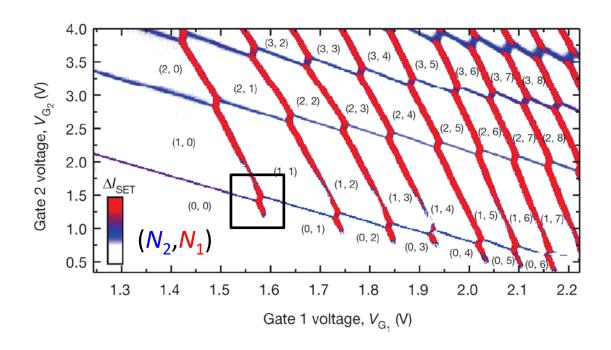
Rev. Mod. Phys. **75**, 1 (2003) van der Wiel *et al.* Rev. Mod. Phys. **79**, 1217 (2007) Hanson *et al.*

振る舞う

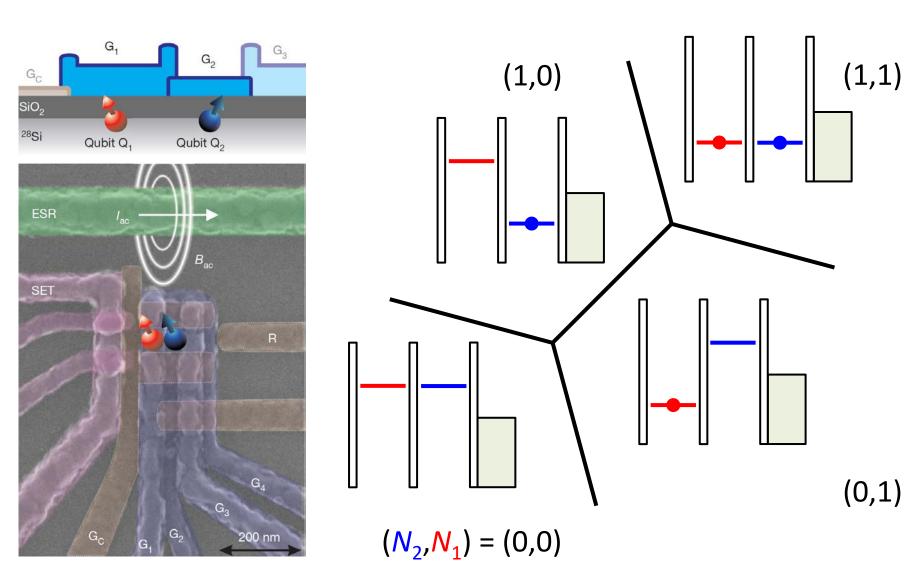
MOS型2重量子ドット



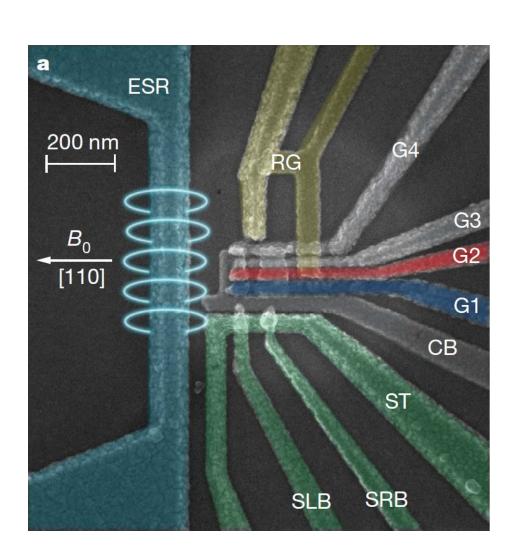




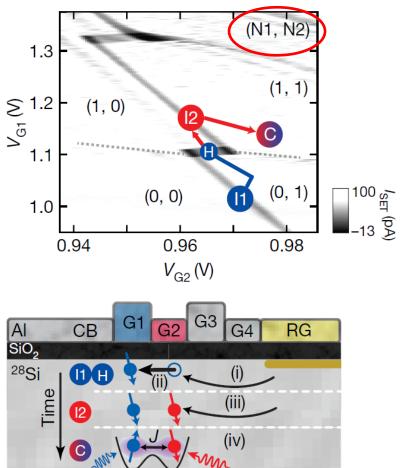
MOS型2重量子ドット



量子ビット操作

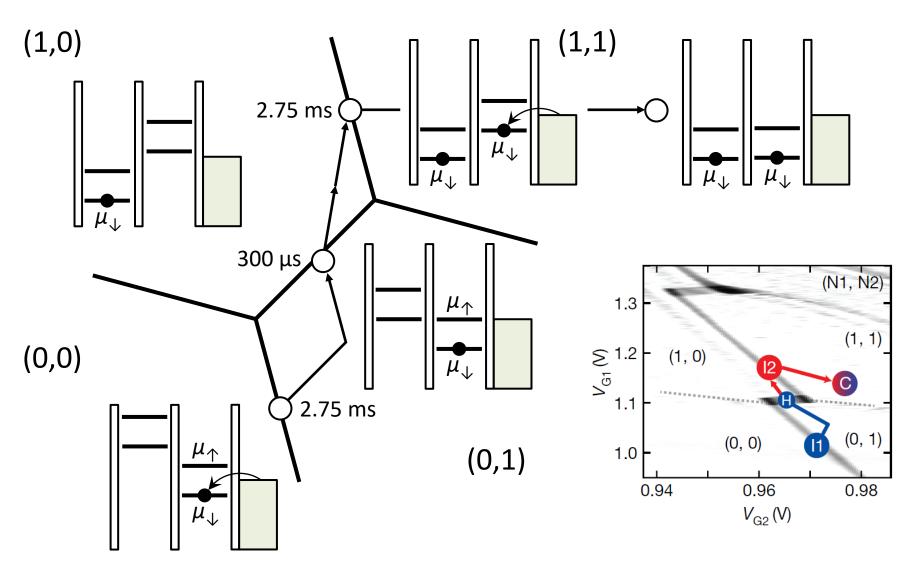


*Q₁, Q₂の同じ並び方



Nature **569**, 532 (2019) Huang et al.

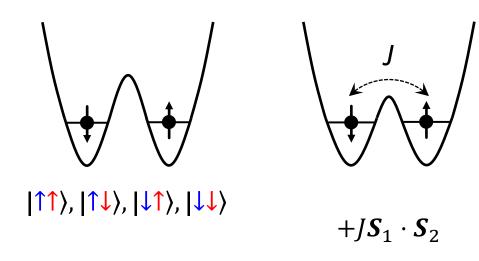
スピン初期化



Nature **569**, 532 (2019) Huang et al.

2スピン状態

量子ドット閉じ込めポテンシャル

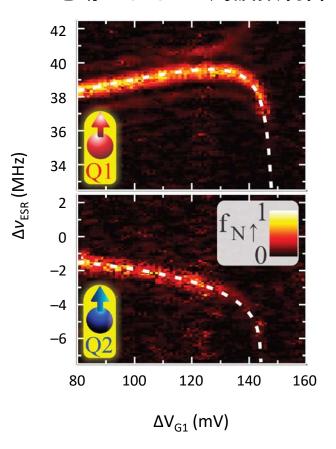


$$H = \gamma_{e,1}B_0(S_{z,1} \otimes I) + \gamma_{e,2}B_0(I \otimes S_{z,2})$$

*低磁場におけるSi:Pのスピンハミルトニアンと形式上同じ形(なので、ここで解きません)

$$H = \gamma_{\rm e} B_0 S_z - \gamma_{\rm P} B_0 I_z + a_0 \mathbf{S} \cdot \mathbf{I}$$

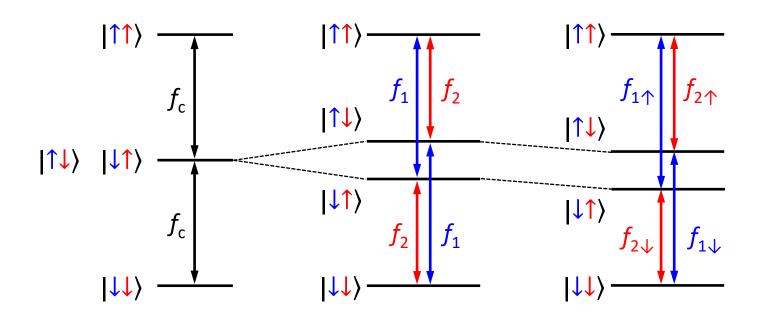
電場によるESR周波数制御



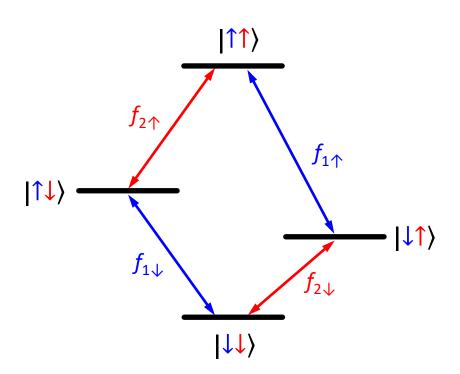
2スピン状態

$$(f_{1\uparrow}, f_{1\downarrow}, f_{2\uparrow}, f_{2\downarrow}) \\ = (\bar{E}_z, 0, 0, -\bar{E}_z) \longrightarrow \left(\bar{E}_z, \frac{\delta E_z}{2}, -\frac{\delta E_z}{2}, -\bar{E}_z\right) \longrightarrow \left(\bar{E}_z, \frac{\delta \tilde{E}_z - J}{2}, -\frac{\delta \tilde{E}_z + J}{2}, -\bar{E}_z\right)$$

$$\overline{E}_z/h = f_c = 39.33 \text{ GHz}$$
 $\delta E_z/h = 13.26 \text{ MHz}$ $\delta \widetilde{E}_z = (\delta E_z^2 + J^2)^{1/2}$ $\partial E_z/h = 1.59 \text{ MHz}$



• 全ての遷移が異なる周波数を持つ



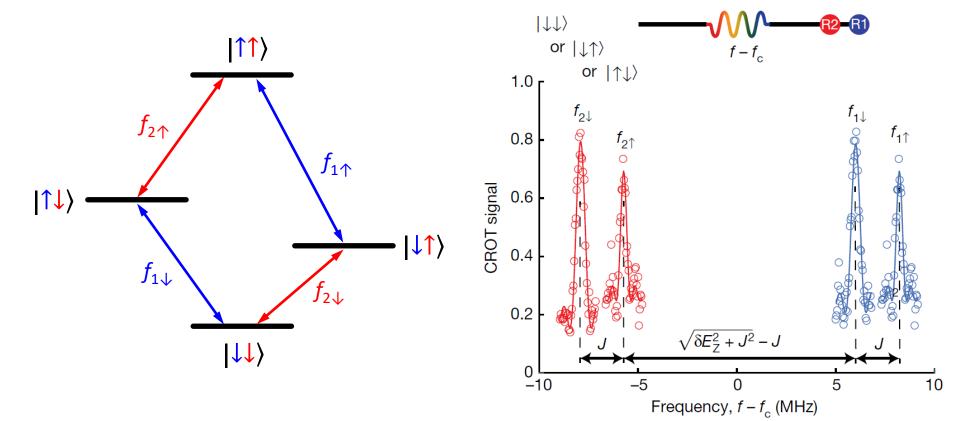
$$f_{1\uparrow} = \bar{E}_z + \frac{\delta \tilde{E}_z + J}{2}$$

$$f_{1\downarrow} = \bar{E}_z + \frac{\delta \tilde{E}_z + J}{2}$$

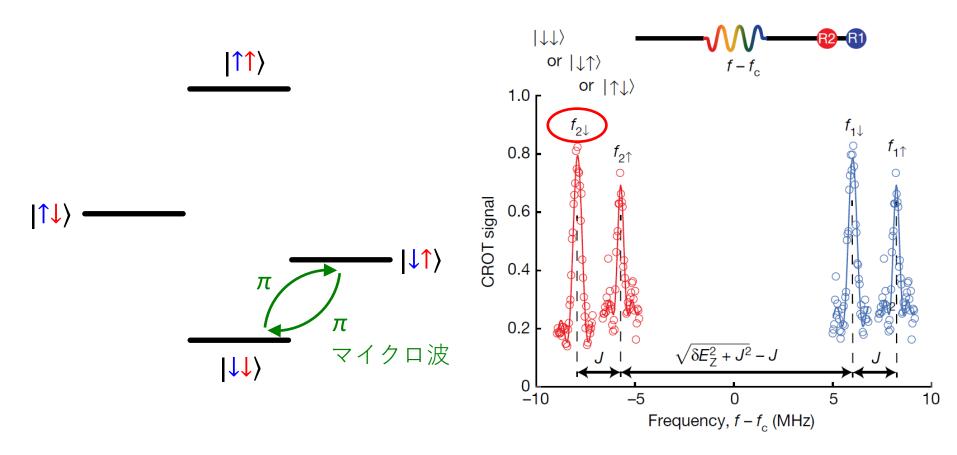
$$f_{2\uparrow} = \bar{E}_z + \frac{-\delta \tilde{E}_z + J}{2}$$

$$f_{2\downarrow} = \bar{E}_z + \frac{-\delta \tilde{E}_z - J}{2}$$

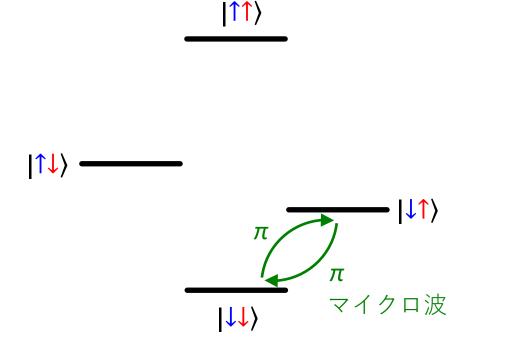
- 全ての遷移が異なる周波数を持つ
- 選択励起のπパルスにより2量子ビットゲートが実現可能



- 全ての遷移が異なる周波数を持つ
- 選択励起のπパルスにより2量子ビットゲートが実現可能



- 全ての遷移が異なる周波数を持つ
- 選択励起のπパルスにより2量子ビットゲートが実現可能

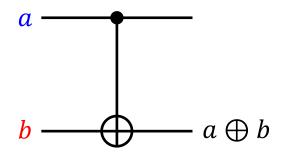


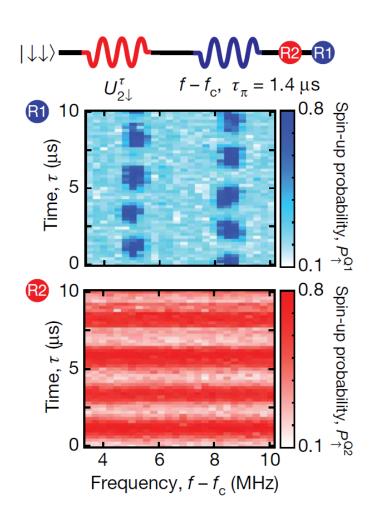
$$|\uparrow\uparrow\rangle = |00\rangle \longrightarrow |00\rangle$$

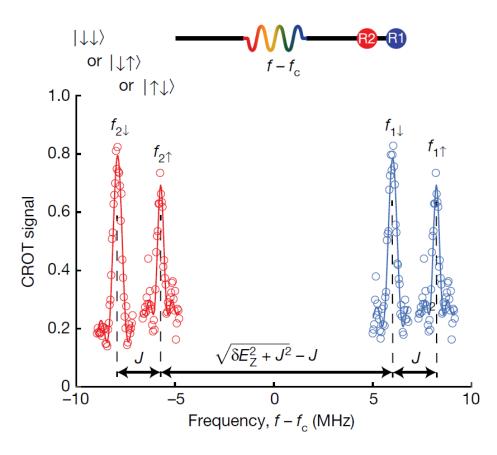
$$|\uparrow\downarrow\rangle = |01\rangle \longrightarrow |01\rangle$$

$$|\downarrow\uparrow\rangle = |10\rangle \longrightarrow |11\rangle$$

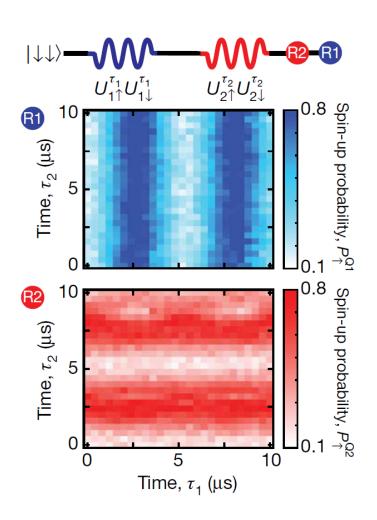
$$|\downarrow\downarrow\rangle = |11\rangle \longrightarrow |10\rangle$$

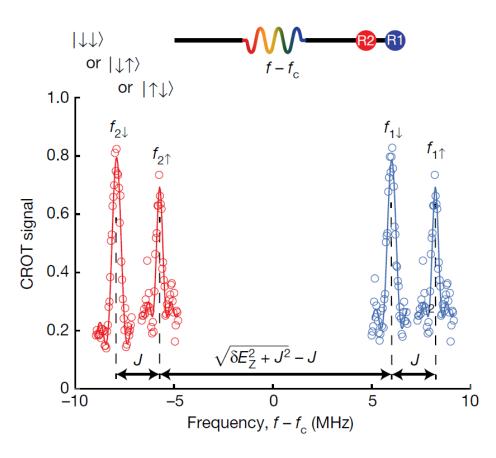




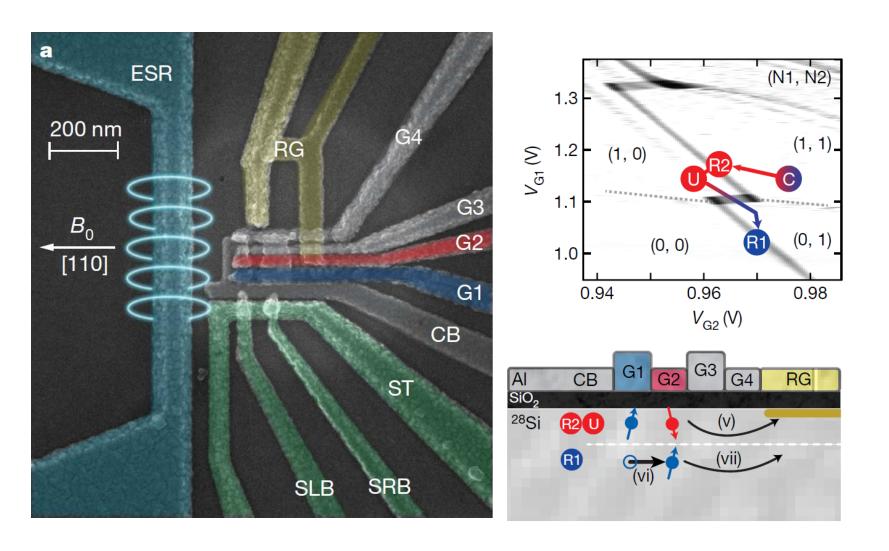


1量子ビットゲート





スピン読み出し



"高温"動作

Article

Operation of a silicon quantum processor unit cell above one kelvin

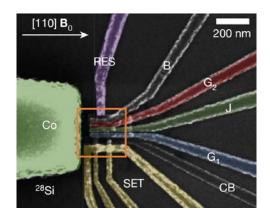
https://doi.org/10.1038/s41586-020-2171-6

Received: 19 June 2019

Accepted: 22 January 2020

Published online: 15 April 2020

C. H. Yang^{1, ...}, R. C. C. Leon¹, J. C. C. Hwang^{1,6}, A. Saraiva¹, T. Tanttu¹, W. Huang¹, J. Camirand Lemyre², K. W. Chan¹, K. Y. Tan^{3,7}, F. E. Hudson¹, K. M. Itoh⁴, A. Morello¹, M. Pioro-Ladrière^{2,5}, A. Laucht¹ & A. S. Dzurak^{1,...}



Article

Universal quantum logic in hot silicon qubits

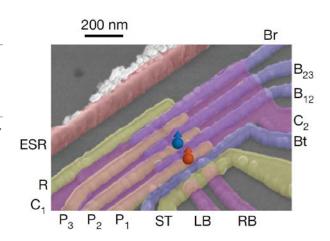
https://doi.org/10.1038/s41586-020-2170-7

Received: 22 October 2019

Accepted: 22 January 2020

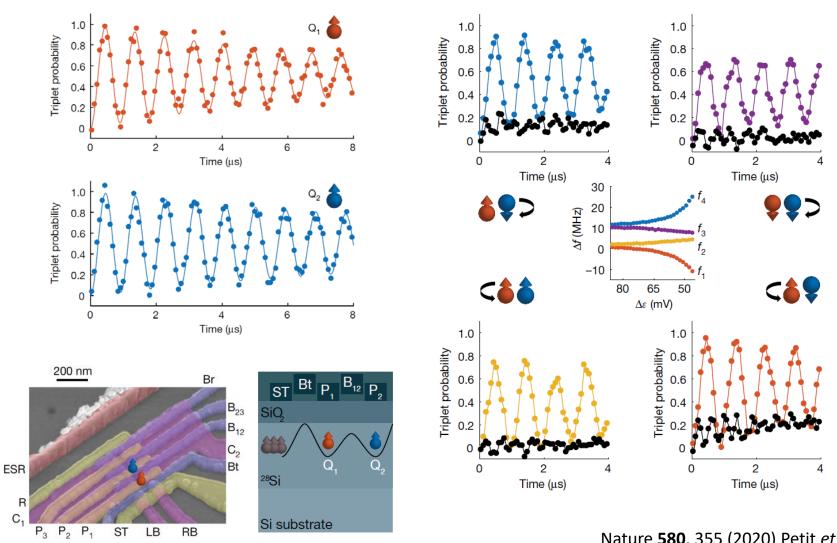
Published online: 15 April 2020

L. Petit¹, H. G. J. Eenink¹, M. Russ¹, W. I. L. Lawrie¹, N. W. Hendrickx¹, S. G. J. Philips¹, J. S. Clarke², L. M. K. Vandersypen¹ & M. Veldhorst¹□



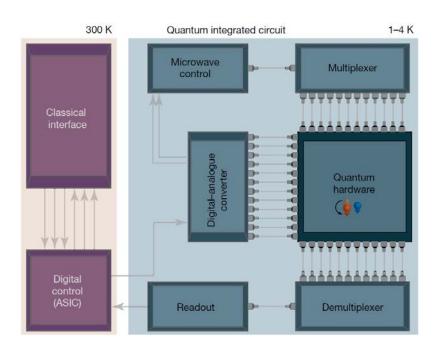
Nature **580**, 350 (2020) Yang *et al.* Nature **580**, 355 (2020) Petit *et al.*

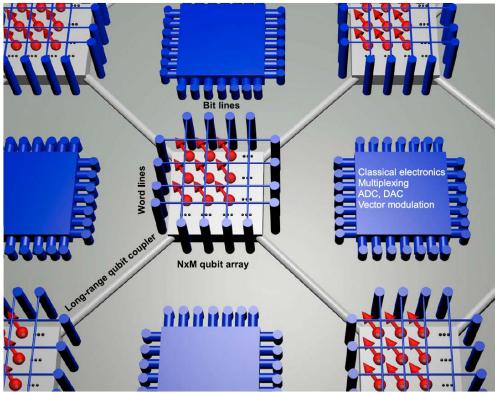
"高温"動作



Nature 580, 355 (2020) Petit et al.

"高温"動作





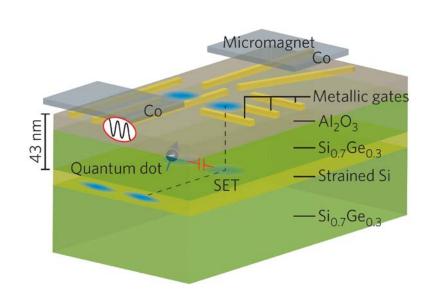
npj Quant. Info. **3**, 34 (2017) Vandersypen et al.

Nature **580**, 355 (2020) Petit et al.

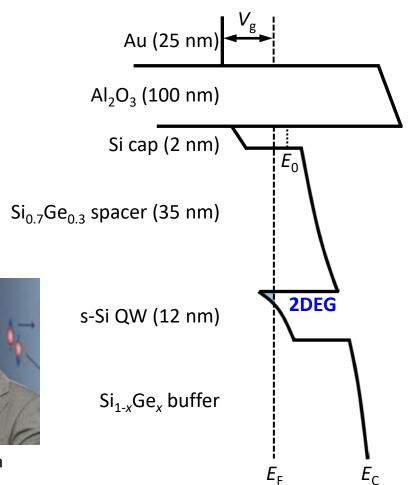
講義內容

- ・ドナースピン
 - アンサンブル
 - 単一ドナー
- 量子ドットスピン
 - MOS量子ドット
 - Si/SiGe量子ドット

Si/SiGeへテロ構造



ノンドープ構造による蓄積型QD





L. Vandersypen ©QuTech, TU Delft



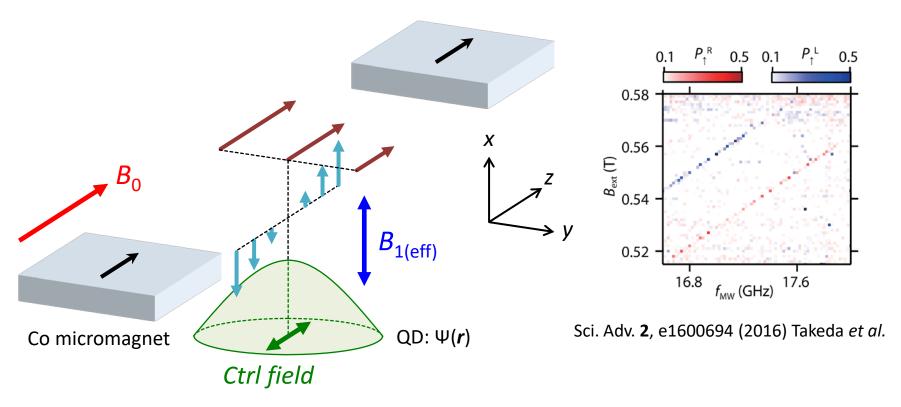
J. Petta

©Princeton

S. Tarucha **©RIKEN**

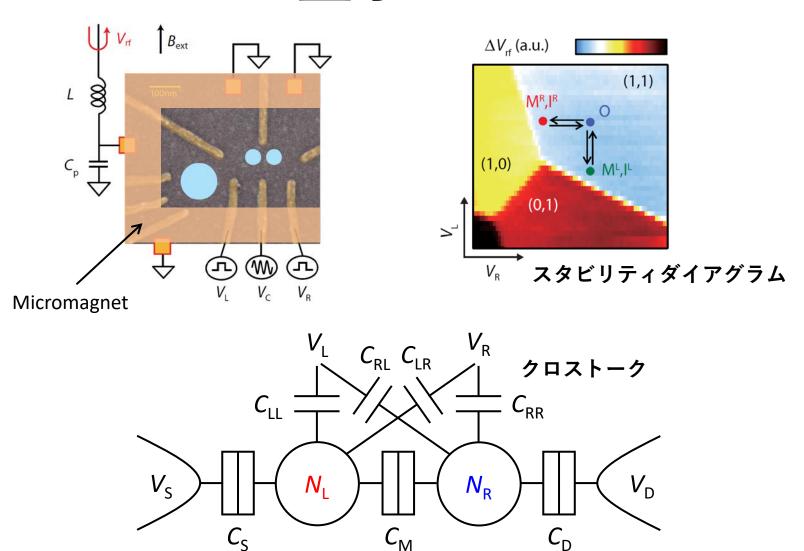
電気双極子スピン共鳴

- **y方向の磁場勾配**によって共鳴周波数を制御
- ±z方向に電子波動関数を"揺する"ことでx方向に実効的な交流磁場を生成

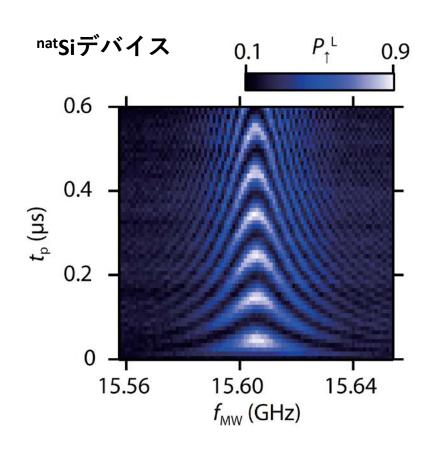


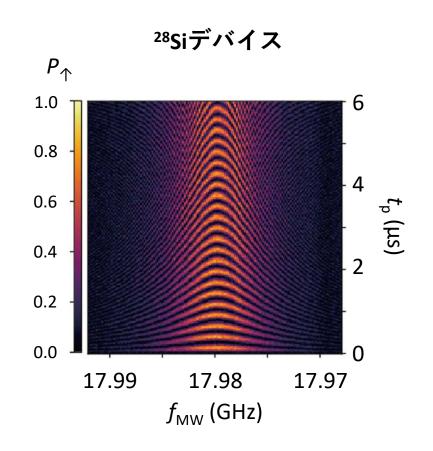
(Theory) Phys. Rev. Lett. 96, 047202 (2006) Tokura *et al.* (GaAs QD) Nature Phys. **4**, 776 (2008) Pioro-Ladrière *et al.* (Magnet design) Appl. Phys. Express **8**, 084401 (2015) Yoneda *et al.*

2重量子ドット



電気双極子スピン共鳴

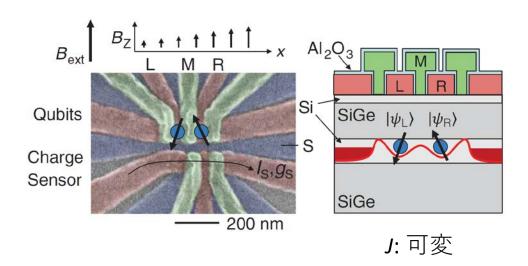


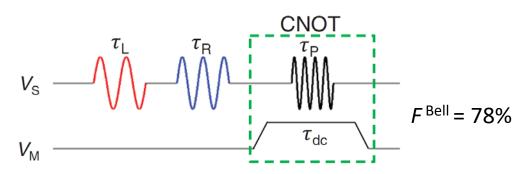


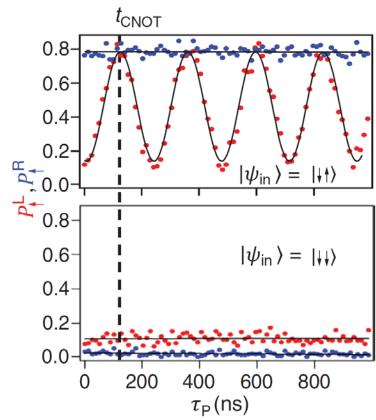
- ラビ周波数 *f*_R ≈ 30 MHz
- フィデリティ*F*^{RB} = 99.6% → > **99.9%**
- $T_2^* = 2 \mu s \rightarrow 20 \mu s$, $T_2^{CPMG} = 3.1 \text{ ms}$

Sci. Adv. **2**, e1600694 (2016) Takeda *et al.*Nature Nano. **13**, 102 (2018) Yoneda *et al.*

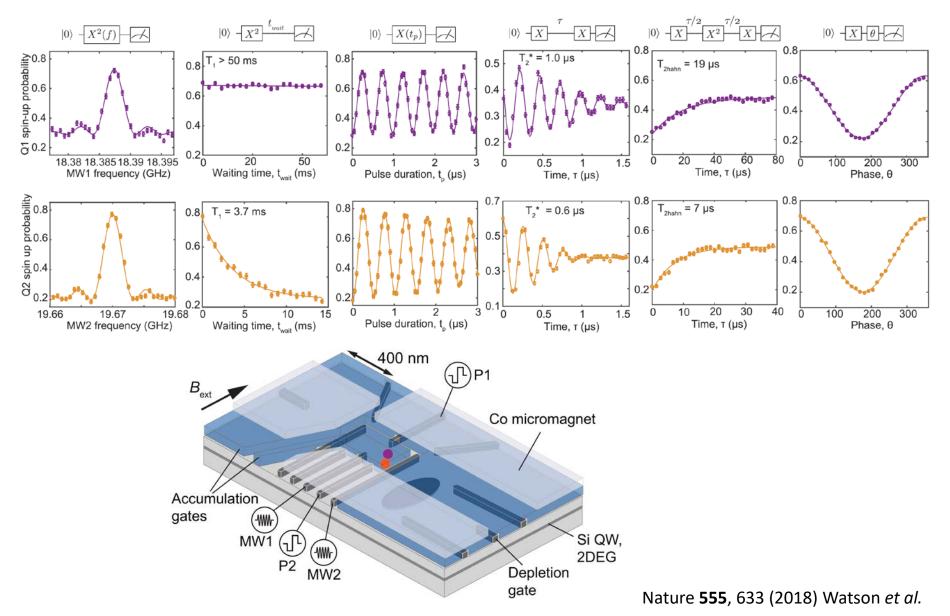
CNOTゲート



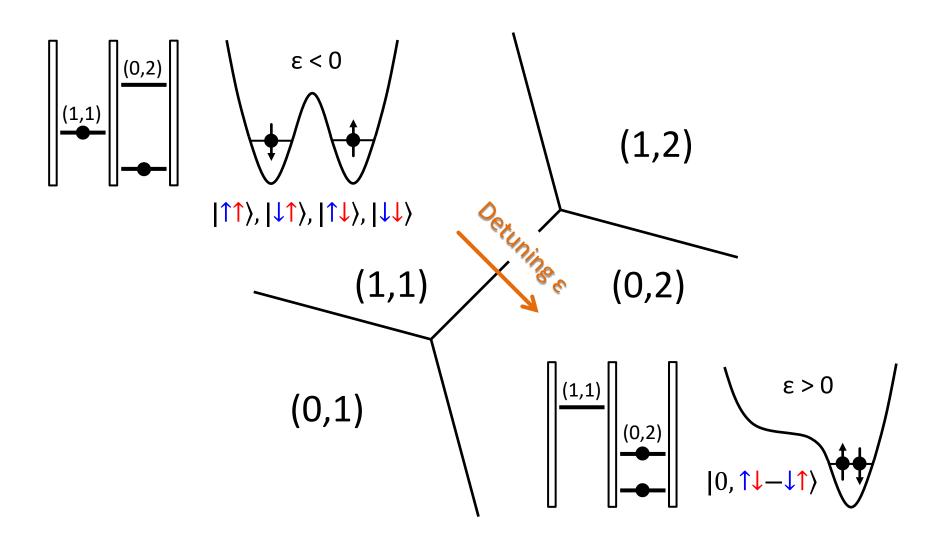




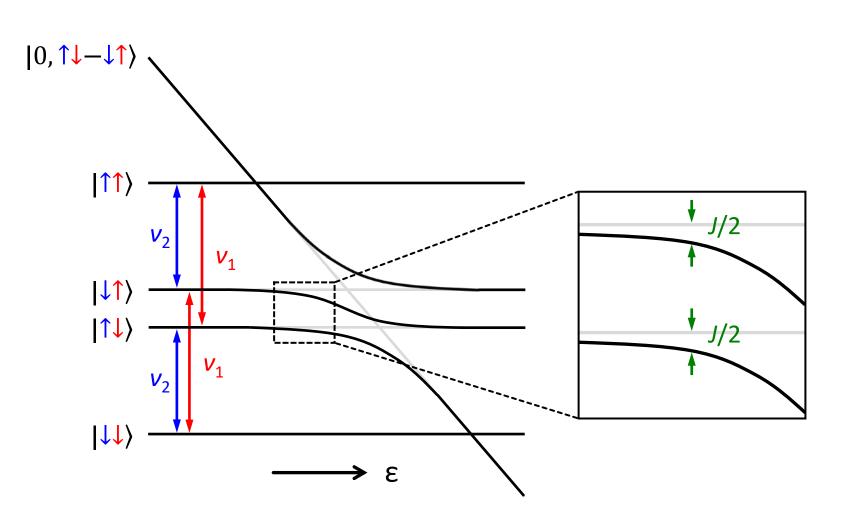
2量子ビットプロセッサ

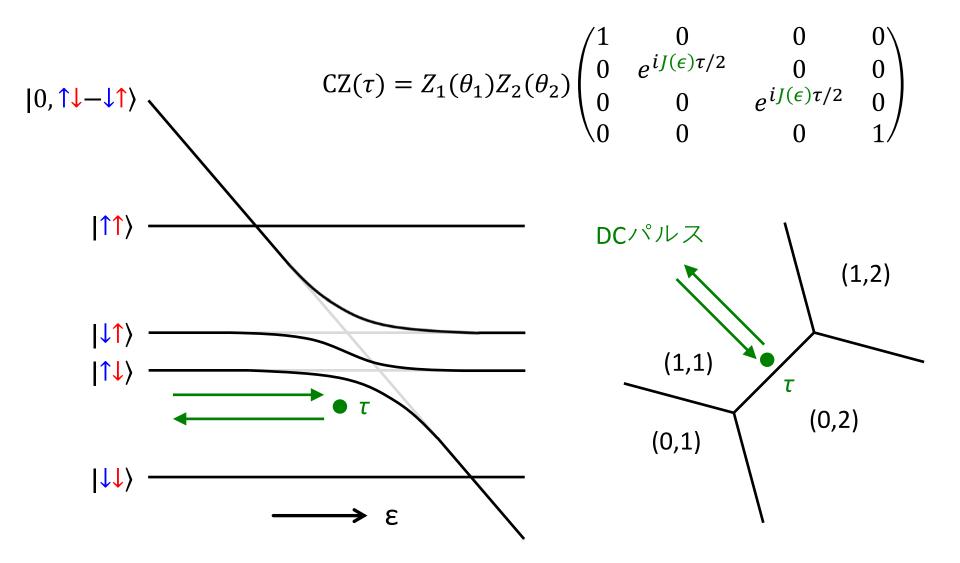


2電子状態



2電子状態



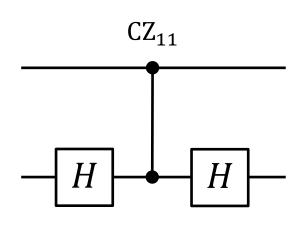


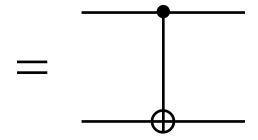
$$CZ_{00} = \begin{pmatrix} -1 & 0 & 0 & 0 \\ 0 & 1 & 0 & 0 \\ 0 & 0 & 1 & 0 \\ 0 & 0 & 0 & 1 \end{pmatrix}$$

$$CZ_{01} = \begin{pmatrix} 1 & 0 & 0 & 0 \\ 0 & -1 & 0 & 0 \\ 0 & 0 & 1 & 0 \\ 0 & 0 & 0 & 1 \end{pmatrix}$$

$$CZ_{10} = \begin{pmatrix} 1 & 0 & 0 & 0 \\ 0 & 1 & 0 & 0 \\ 0 & 0 & -1 & 0 \\ 0 & 0 & 0 & 1 \end{pmatrix}$$

$$CZ_{11} = \begin{pmatrix} 1 & 0 & 0 & 0 \\ 0 & 1 & 0 & 0 \\ 0 & 0 & 1 & 0 \\ 0 & 0 & 0 & -1 \end{pmatrix}$$





 $CNOT = H_2CZ_{11}H_2$

$$CZ_{00} = \begin{pmatrix} -1 & 0 & 0 & 0 \\ 0 & 1 & 0 & 0 \\ 0 & 0 & 1 & 0 \\ 0 & 0 & 0 & 1 \end{pmatrix} \approx Z_1 \left(\frac{\pi}{2}\right) Z_2 \left(\frac{\pi}{2}\right) CZ_J$$

$$CZ(\tau = 1/J) = Z_1(\theta_1)Z_2(\theta_2) \begin{pmatrix} 1 & 0 & 0 & 0 \\ 0 & i & 0 & 0 \\ 0 & 0 & i & 0 \\ 0 & 0 & 0 & 1 \end{pmatrix} = \begin{pmatrix} 1 & 0 & 0 & 0 \\ 0 & -1 & 0 & 0 \\ 0 & 0 & -1 & 0 \\ 0 & 0 & 0 & -1 \end{pmatrix}$$

$$CZ_I$$

$$Z(\theta) = \begin{pmatrix} e^{-i\theta/2} & 0 \\ 0 & e^{i\theta/2} \end{pmatrix} \longrightarrow Z\left(\frac{\pi}{2}\right) = \begin{pmatrix} e^{-i\pi/4} & 0 \\ 0 & e^{i\pi/4} \end{pmatrix} \approx \begin{pmatrix} 1 & 0 \\ 0 & i \end{pmatrix}$$

$$Z_{1}\left(\frac{\pi}{2}\right) \otimes Z_{2}\left(\frac{\pi}{2}\right) = \begin{pmatrix} 1 & 0 \\ 0 & i \end{pmatrix} \otimes \begin{pmatrix} 1 & 0 \\ 0 & i \end{pmatrix} = \begin{pmatrix} 1 & 0 & 0 & 0 \\ 0 & i & 0 & 0 \\ 0 & 0 & i & 0 \\ 0 & 0 & 0 & -1 \end{pmatrix}$$

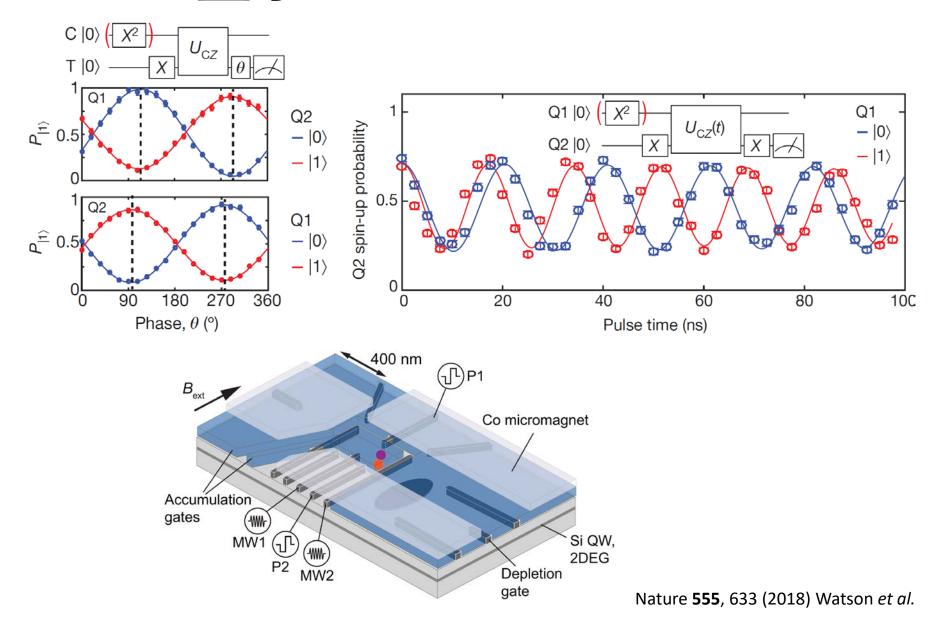
$$CZ_{00} = \begin{pmatrix} -1 & 0 & 0 & 0 \\ 0 & 1 & 0 & 0 \\ 0 & 0 & 1 & 0 \\ 0 & 0 & 0 & 1 \end{pmatrix} \approx Z_1 \left(\frac{\pi}{2}\right) Z_2 \left(\frac{\pi}{2}\right) CZ_J \qquad Z\left(-\frac{\pi}{2}\right) \approx \begin{pmatrix} i & 0 \\ 0 & 1 \end{pmatrix}$$

$$CZ_{01} = \begin{pmatrix} 1 & 0 & 0 & 0 \\ 0 & -1 & 0 & 0 \\ 0 & 0 & 1 & 0 \\ 0 & 0 & 0 & 1 \end{pmatrix} \approx Z_1 \left(-\frac{\pi}{2} \right) Z_2 \left(\frac{\pi}{2} \right) CZ_J$$

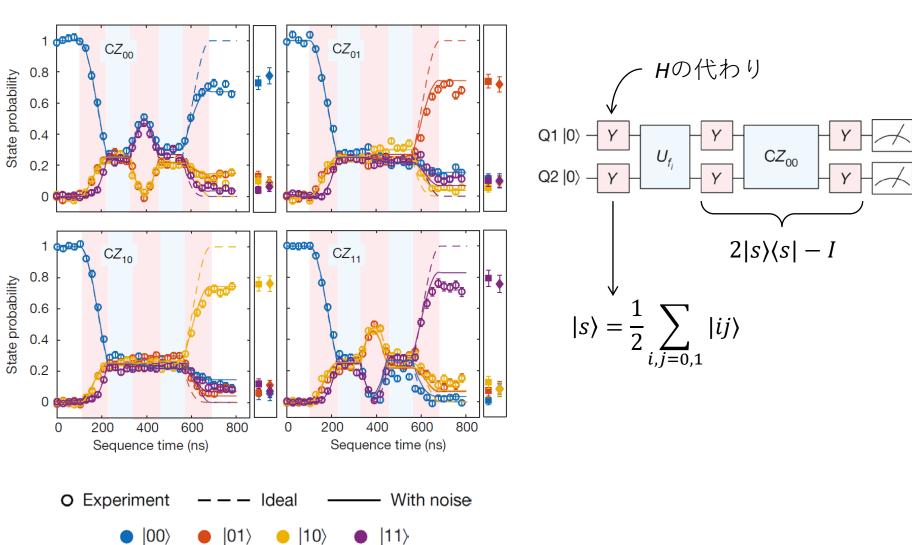
$$CZ_{10} = \begin{pmatrix} 1 & 0 & 0 & 0 \\ 0 & 1 & 0 & 0 \\ 0 & 0 & -1 & 0 \\ 0 & 0 & 0 & 1 \end{pmatrix} \approx Z_1 \left(\frac{\pi}{2}\right) Z_2 \left(-\frac{\pi}{2}\right) CZ_J$$

$$CZ_{11} = \begin{pmatrix} 1 & 0 & 0 & 0 \\ 0 & 1 & 0 & 0 \\ 0 & 0 & 1 & 0 \\ 0 & 0 & 0 & -1 \end{pmatrix} \approx Z_1 \left(-\frac{\pi}{2} \right) Z_2 \left(-\frac{\pi}{2} \right) CZ_J$$

2量子ビットプロセッサ



グローバーのアルゴリズムの実行



シリコンスピンの実験の現状

方式	1量子ビット	2量子ビット	多量子ビット化
単一リンドナー	$T_{2e}^{CPMG} = 559 \text{ ms}$ $T_{2n+}^{CPMG} = 35.6 \text{ s}$ $F_{2n+} = 99.99\% (*1)$	cf. $F_{ZZ,\sqrt{S}} = 90\%$ (*4) cf. $F^{\text{Bell(e-n)}} = 97\%$ (*5)	"フリップフロップ " 量子ビット(*8)
MOS量子ドット	$T_2^{\text{CPMG}} = 28 \text{ ms}$ $F^{\text{RB}} = 99.6\% (*2)$	F Bell = 89% F RB = 98% (*6)	CMOS/DRAM技術 との融合, 高温動作 (*9,10)
Si/SiGe量子ドット	$T_2^{\text{CPMG}} = 3.1 \text{ ms}$ $F^{\text{RB}} > 99.9\% (*3)$	F ^{Bell} = 89% (*7)	スピン –MW 光子結合 による回路QED(*11,12)

^{*1:} Nature Nano. **9**, 986 (2014) Muhonen et al.

^{*2:} Nature Nano. 9, 981 (2014) Veldhorst et al.

^{*3:} Nature Nano. **13**, 102 (2018) Yoneda *et al.*

^{*4:} Nature **571**, 371 (2019) He et al. (donor QDs)

^{*5:} Nature Nano. **11**, 242 (2016) Dehollain *et al.*

^{*6:} Nature **569**, 532 (2019) Huang et al.

^{*7:} Nature **555**, 633 (2018) Watson et al.

^{*8:} Nature Commun. 8, 450 (2017) Tosi et al.

^{*9:} Nature Commun. **8**, 1766 (2017) Veldhorst *et al.*

^{*10:} Sci. Adv. **4**, eaar3960 (2018) Li *et al.*

^{*11:} Nature **555**, 599 (2018) Mi *et al.*

^{*12:} Science **359**, 1123 (2018) Samkharadze et al.

レポート課題3(10点)

CZooの例にならって、以下を示せ。

$$CZ_{01} = \begin{pmatrix} 1 & 0 & 0 & 0 \\ 0 & -1 & 0 & 0 \\ 0 & 0 & 1 & 0 \\ 0 & 0 & 0 & 1 \end{pmatrix} \approx Z_1 \left(-\frac{\pi}{2} \right) Z_2 \left(\frac{\pi}{2} \right) CZ_J$$

$$CZ_{10} = \begin{pmatrix} 1 & 0 & 0 & 0 \\ 0 & 1 & 0 & 0 \\ 0 & 0 & -1 & 0 \\ 0 & 0 & 0 & 1 \end{pmatrix} \approx Z_1 \left(\frac{\pi}{2} \right) Z_2 \left(-\frac{\pi}{2} \right) CZ_J$$

$$CZ_{11} = \begin{pmatrix} 1 & 0 & 0 & 0 \\ 0 & 1 & 0 & 0 \\ 0 & 0 & 1 & 0 \\ 0 & 0 & 0 & 1 \end{pmatrix} \approx Z_1 \left(-\frac{\pi}{2} \right) Z_2 \left(-\frac{\pi}{2} \right) CZ_J$$